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Lardin et al.

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(54) **PORTABLE PANORAMIC LASER MAPPING AND/OR PROJECTION SYSTEM**

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G01S 7/481 (2006.01)
G01S 17/32 (2006.01)
G01S 17/42 (2006.01)
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(58) **Field of Classification Search**
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See application file for complete search history.

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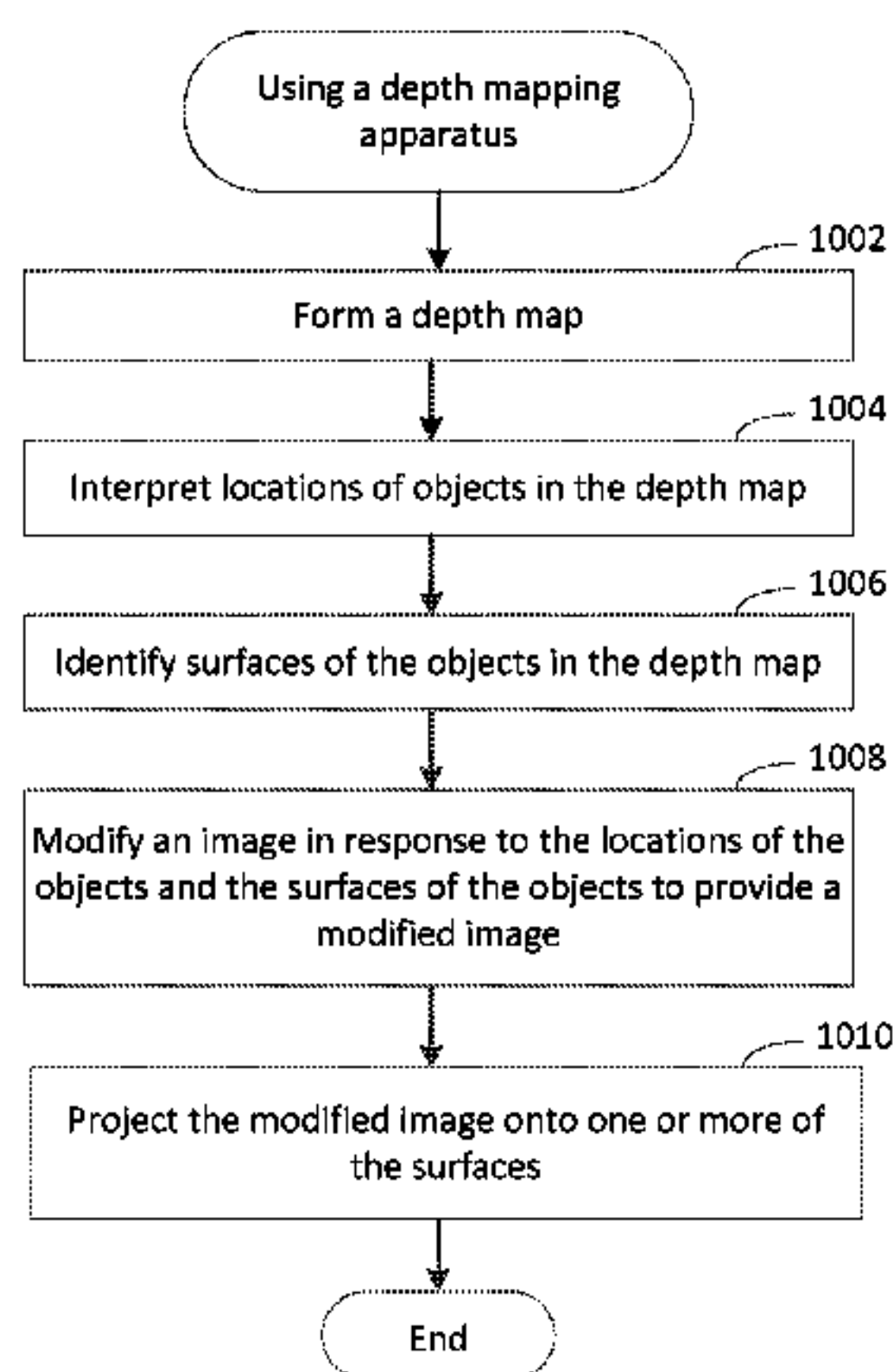
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(57) **ABSTRACT**

Techniques are described herein that are capable of forming a depth map and/or projecting an image onto object(s) based on the depth map. A depth map is a three-dimensional representation of an environment. Forming the depth map may utilize a progressive resolution refinement technique. For example, locating information may be determined in accordance with the progressive resolution refinement technique in response to performing a scan of a current point over a field of view. The current point is a point, selected from a plurality of points (e.g., a grid of points) in the field of view, to which a detection beam of light is directed at a respective time as the scan is performed over the field of view. In accordance with this example, the locating information may be coordinated with the scan to form the depth map.

27 Claims, 13 Drawing Sheets

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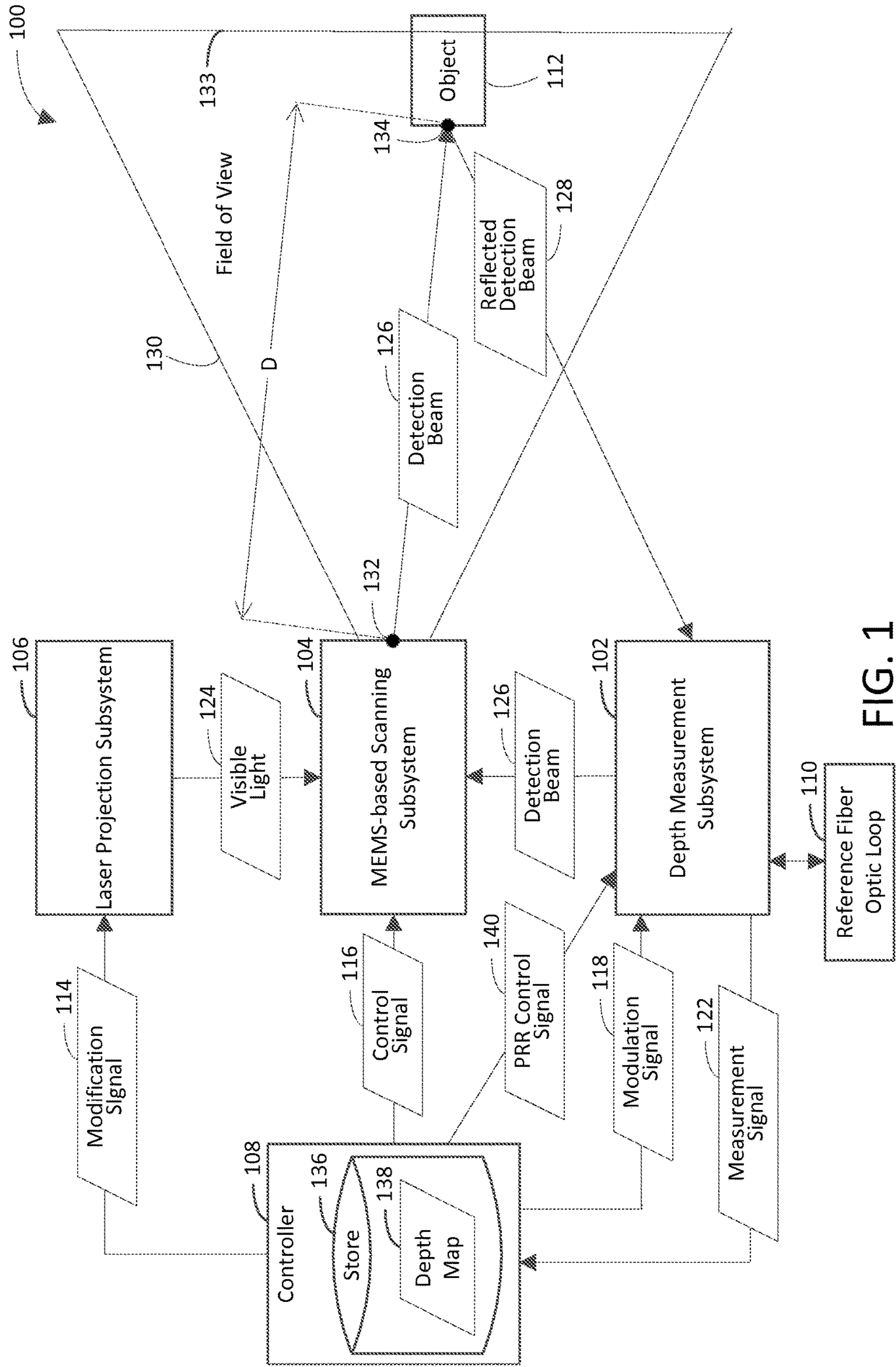


FIG. 1

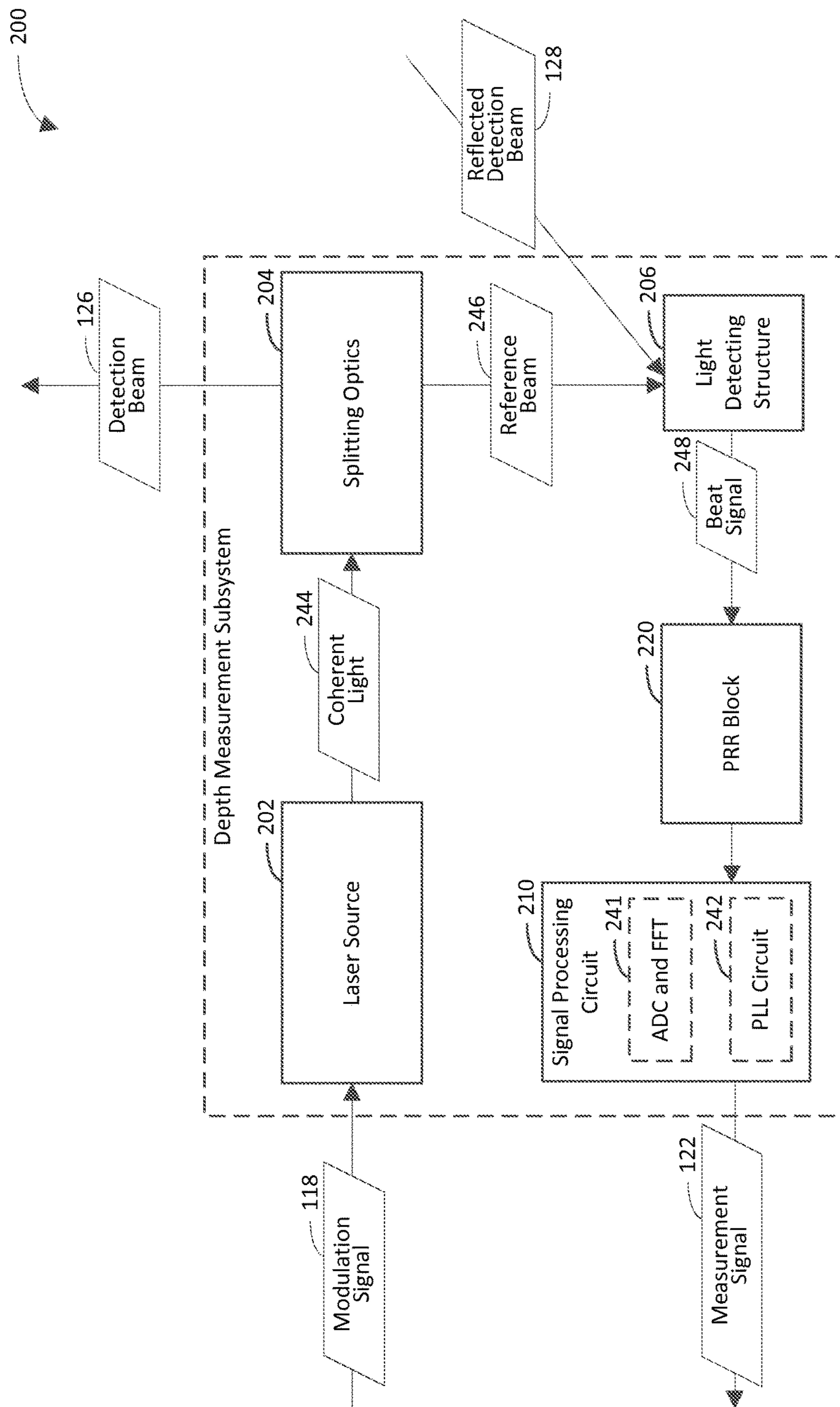


FIG. 2

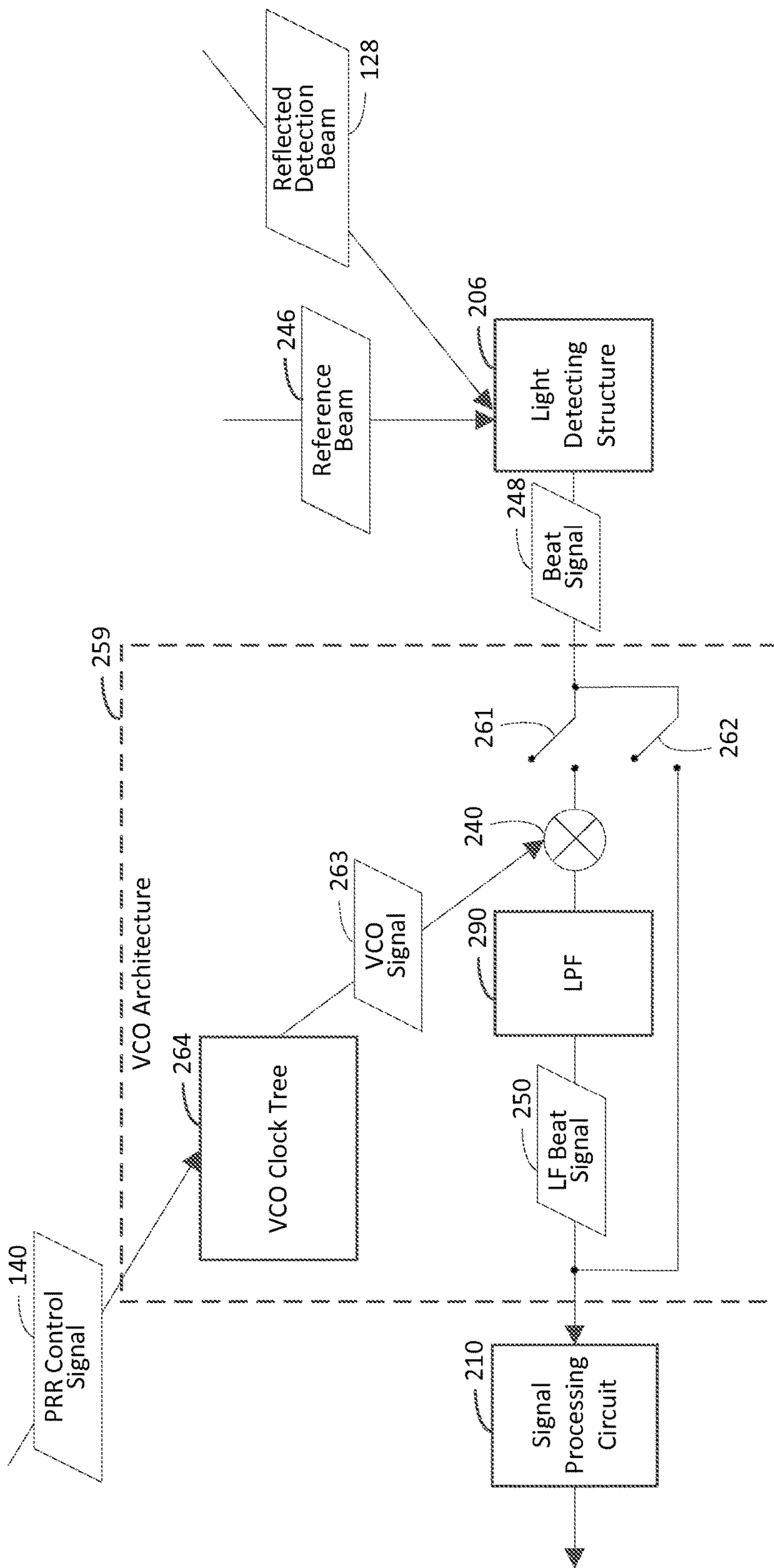


FIG. 2a

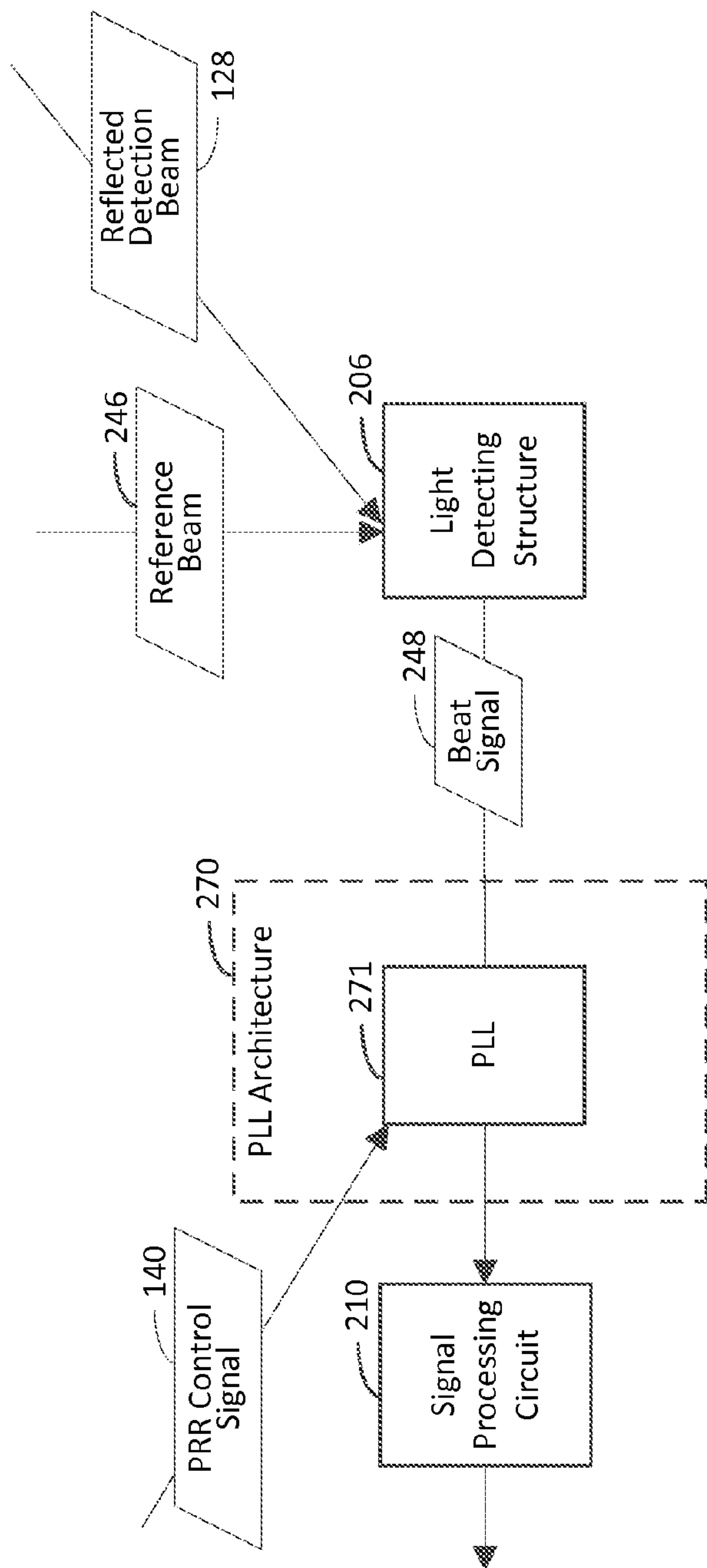


FIG. 2b

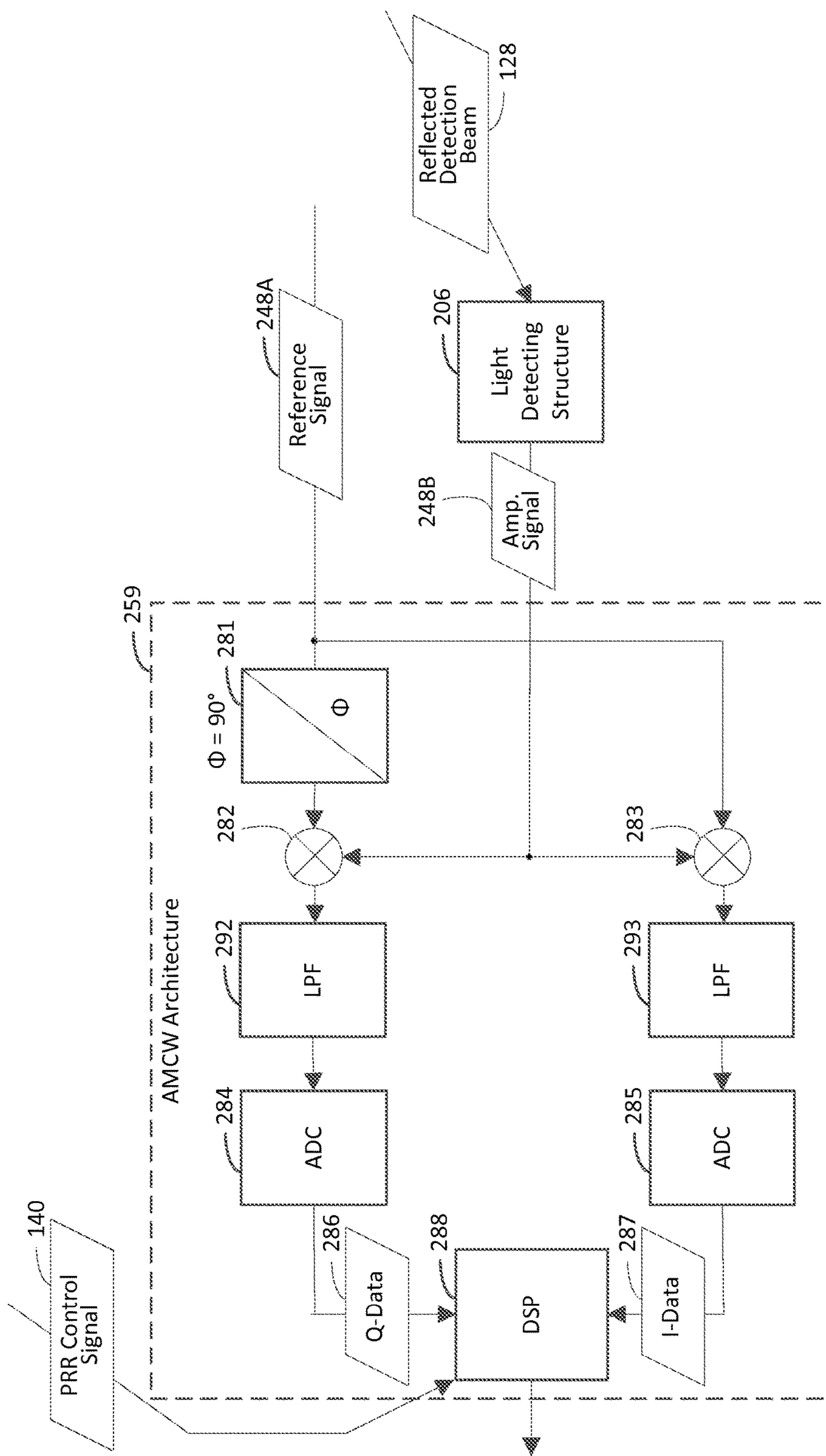


FIG. 2c

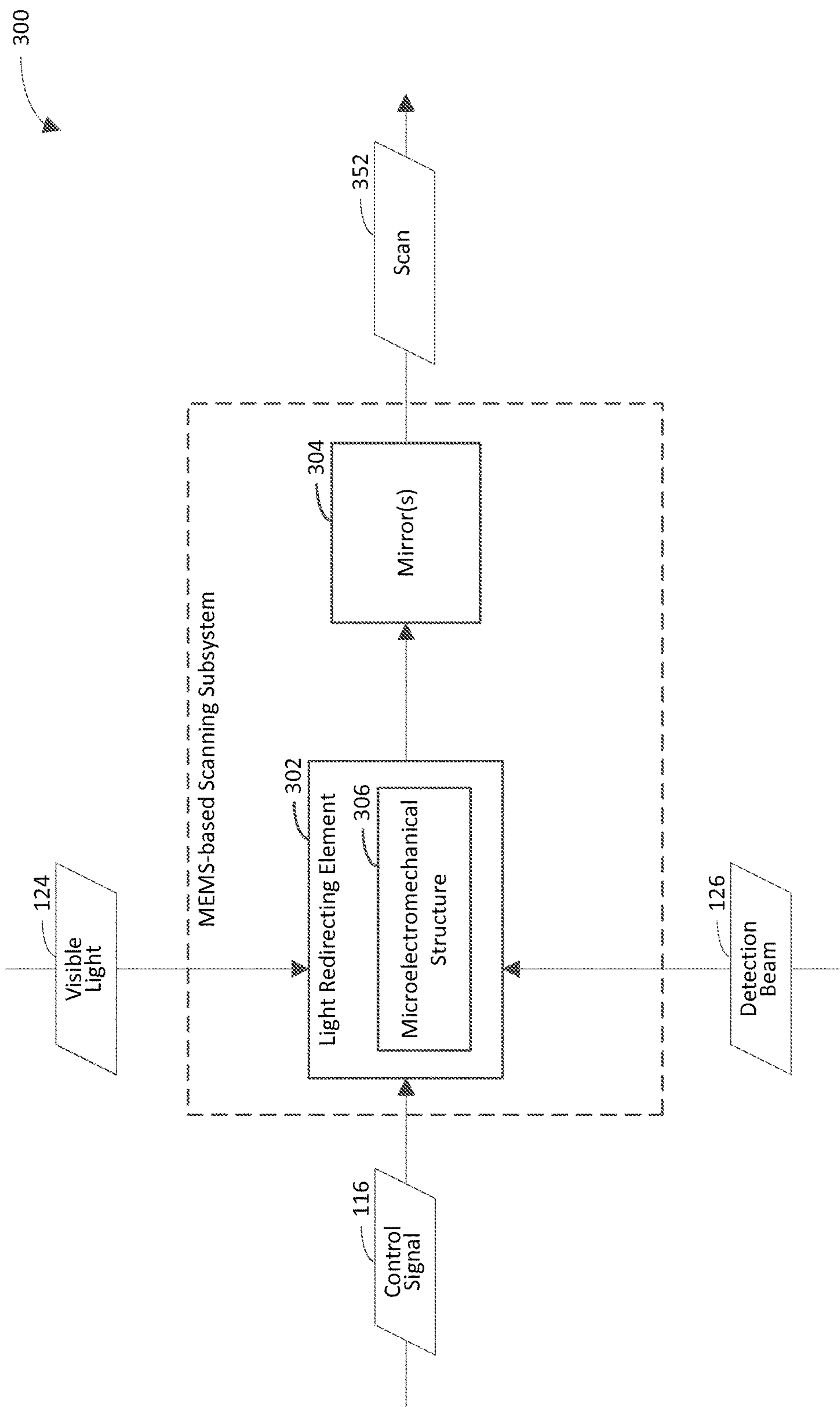


FIG. 3

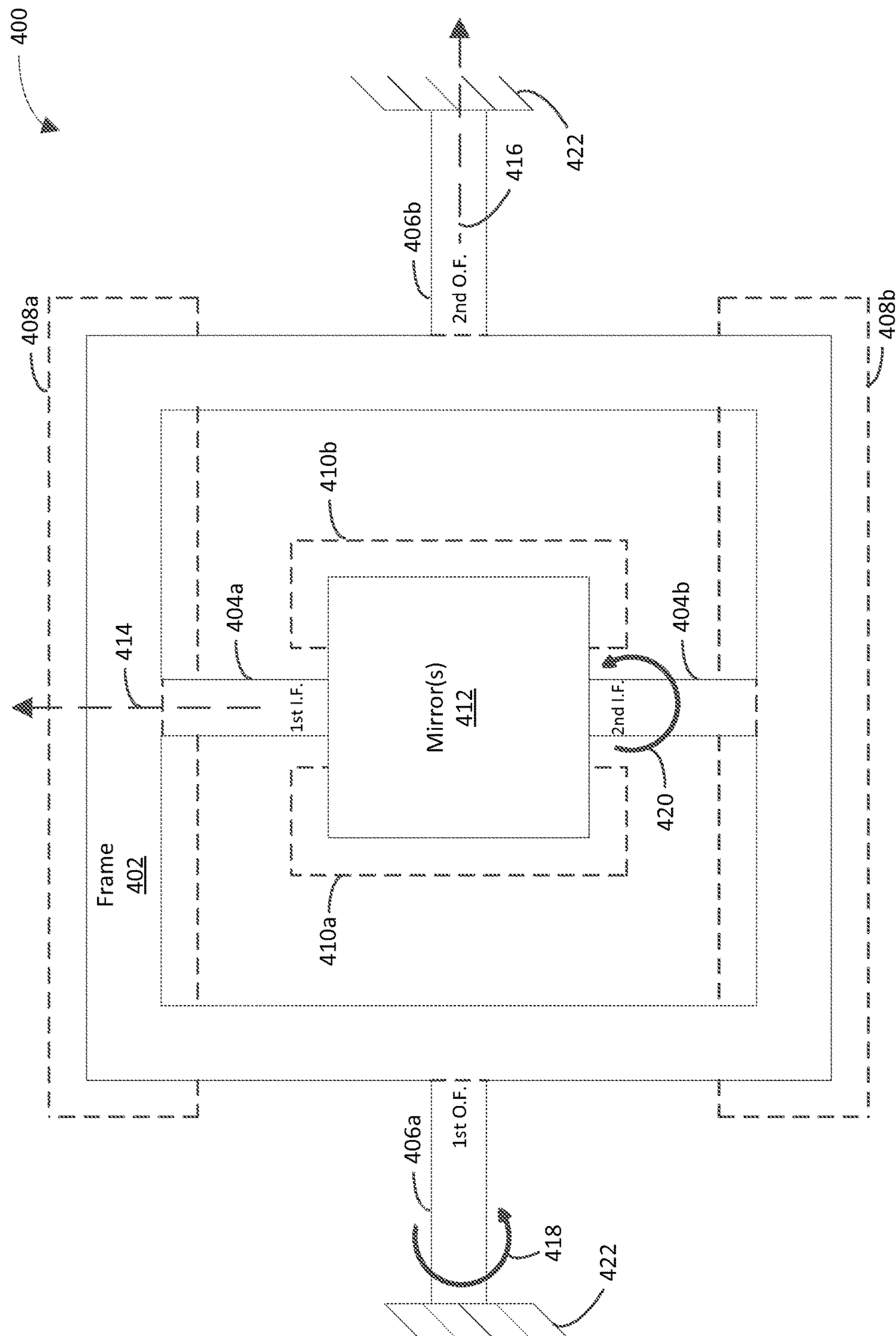


FIG. 4

500

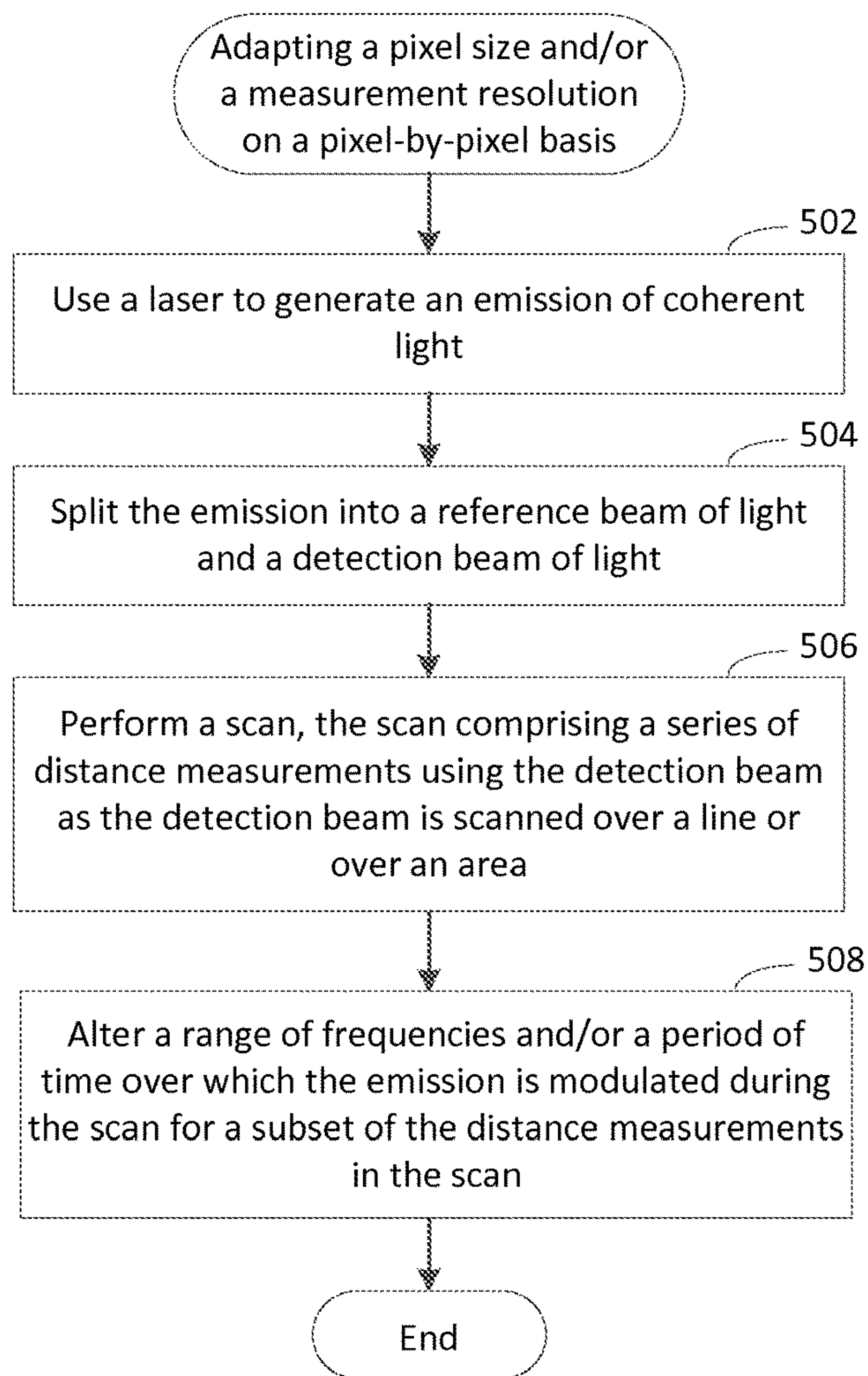


FIG. 5

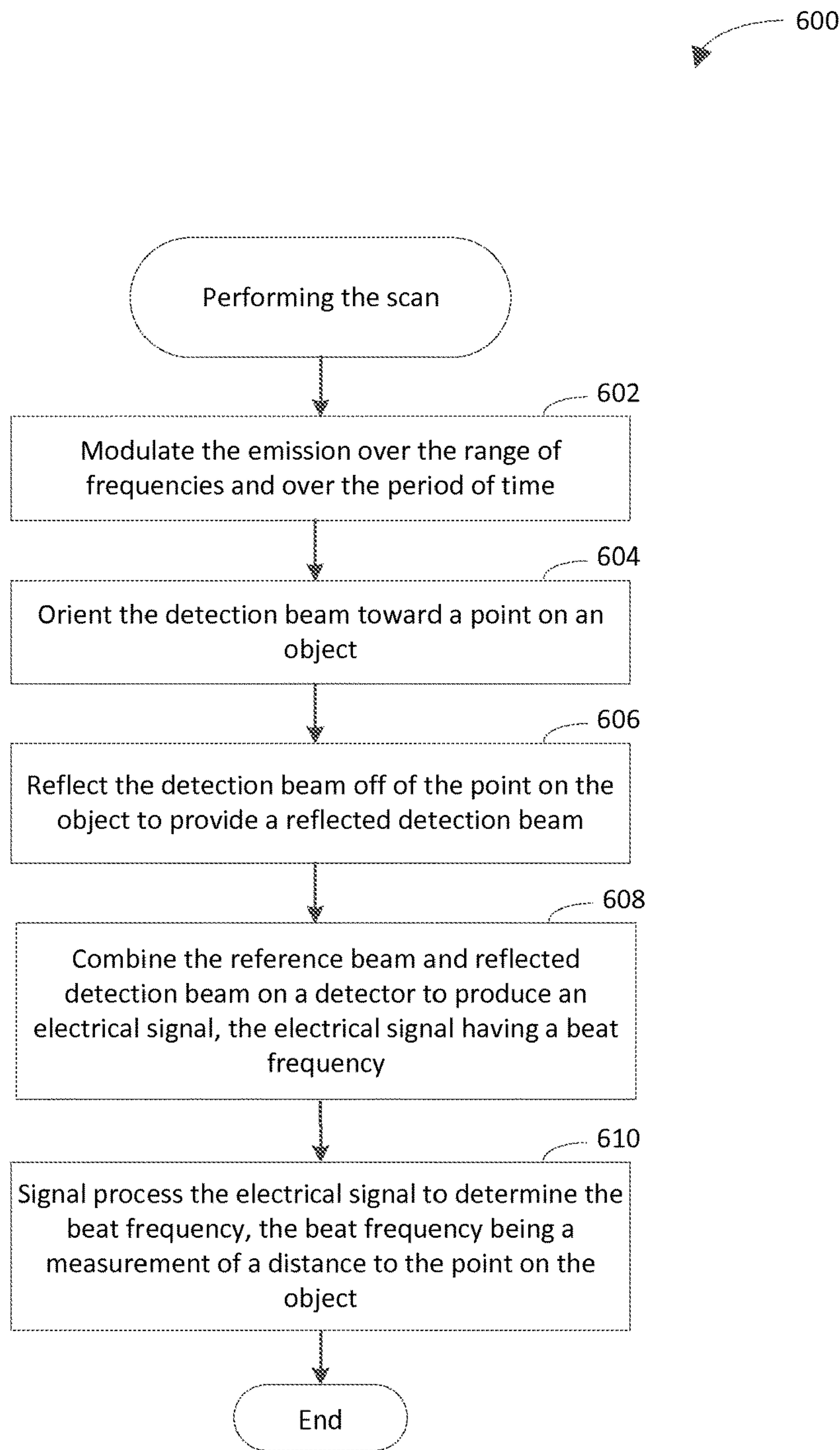


FIG. 6

700

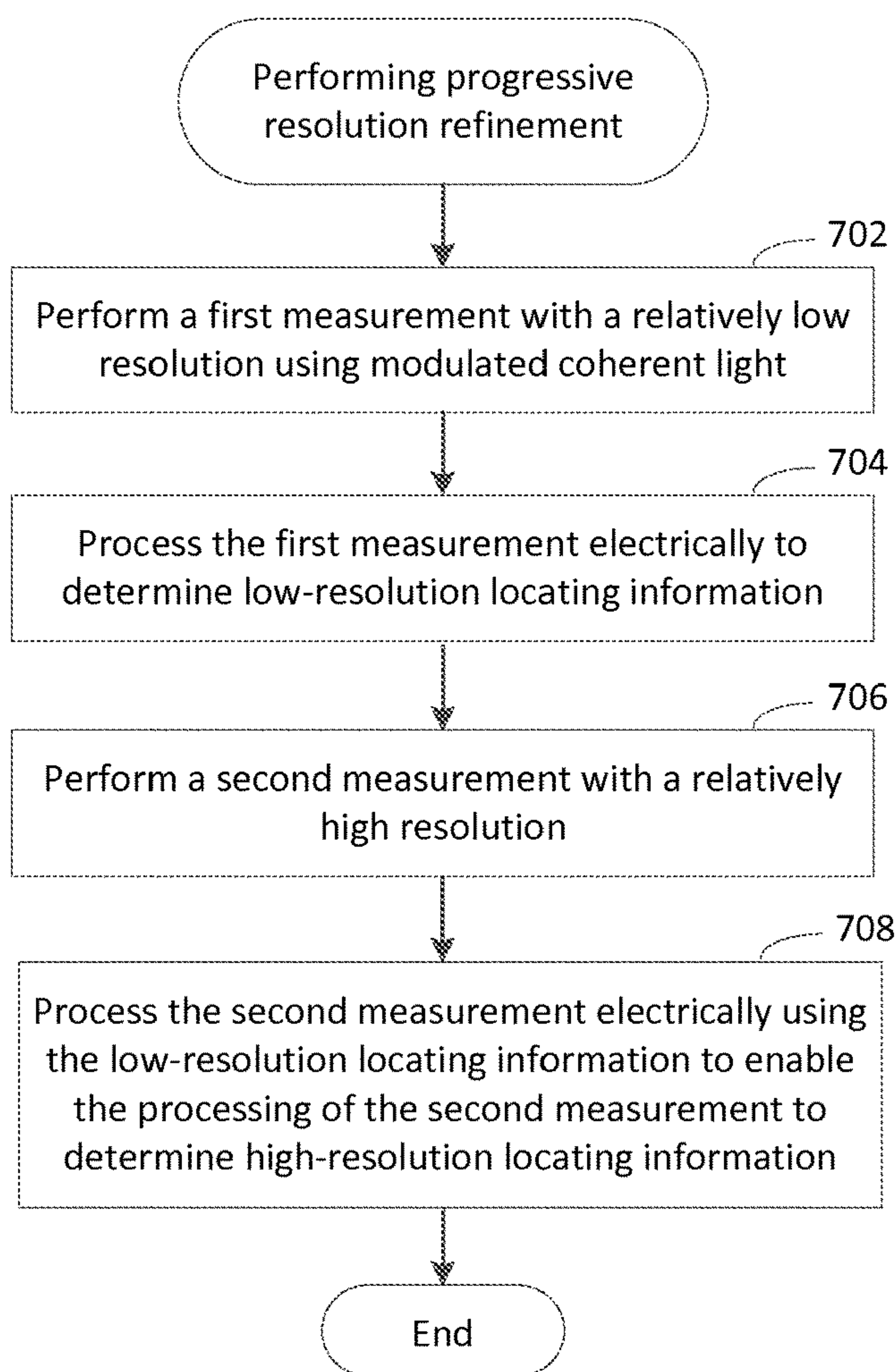


FIG. 7

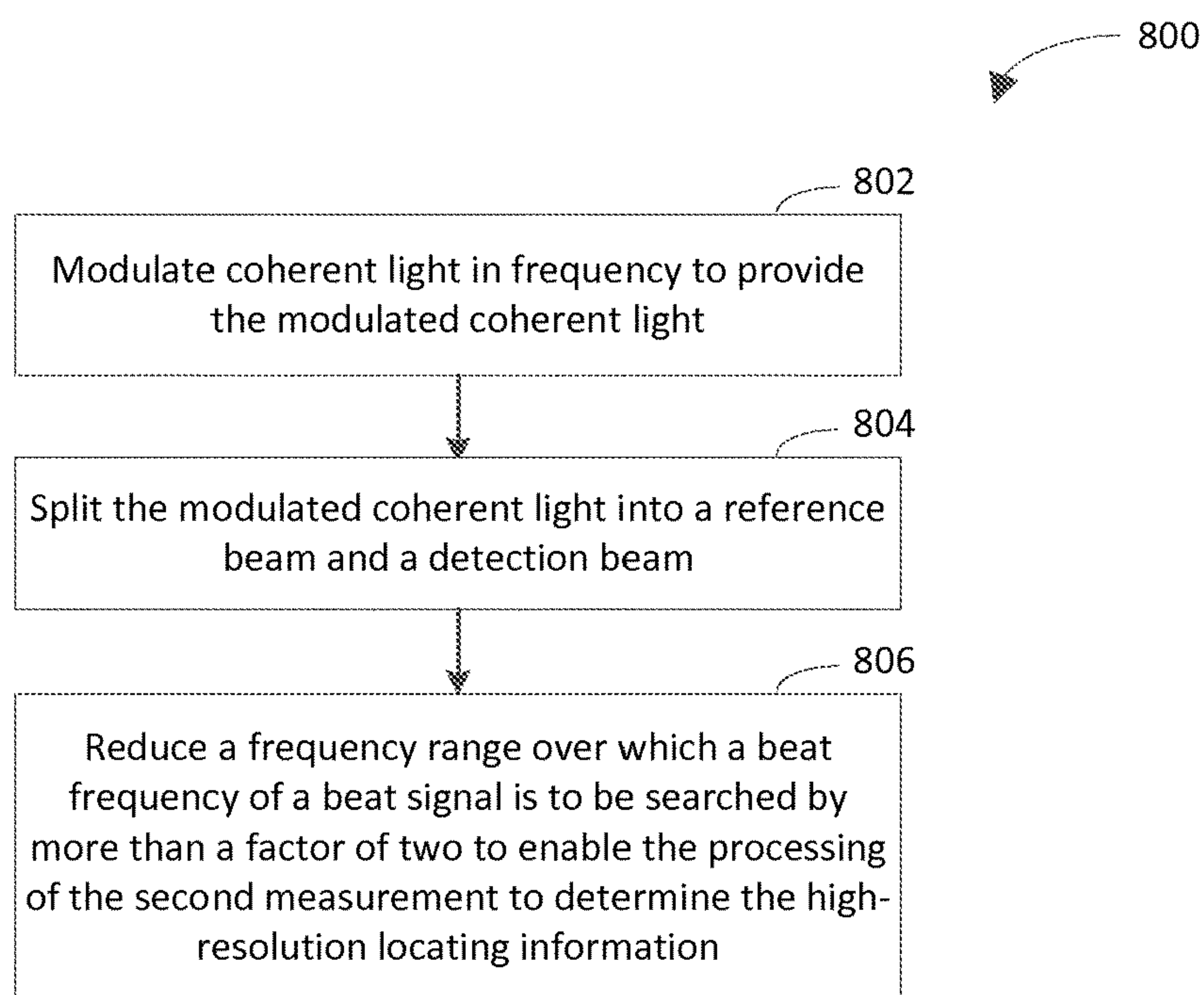


FIG. 8

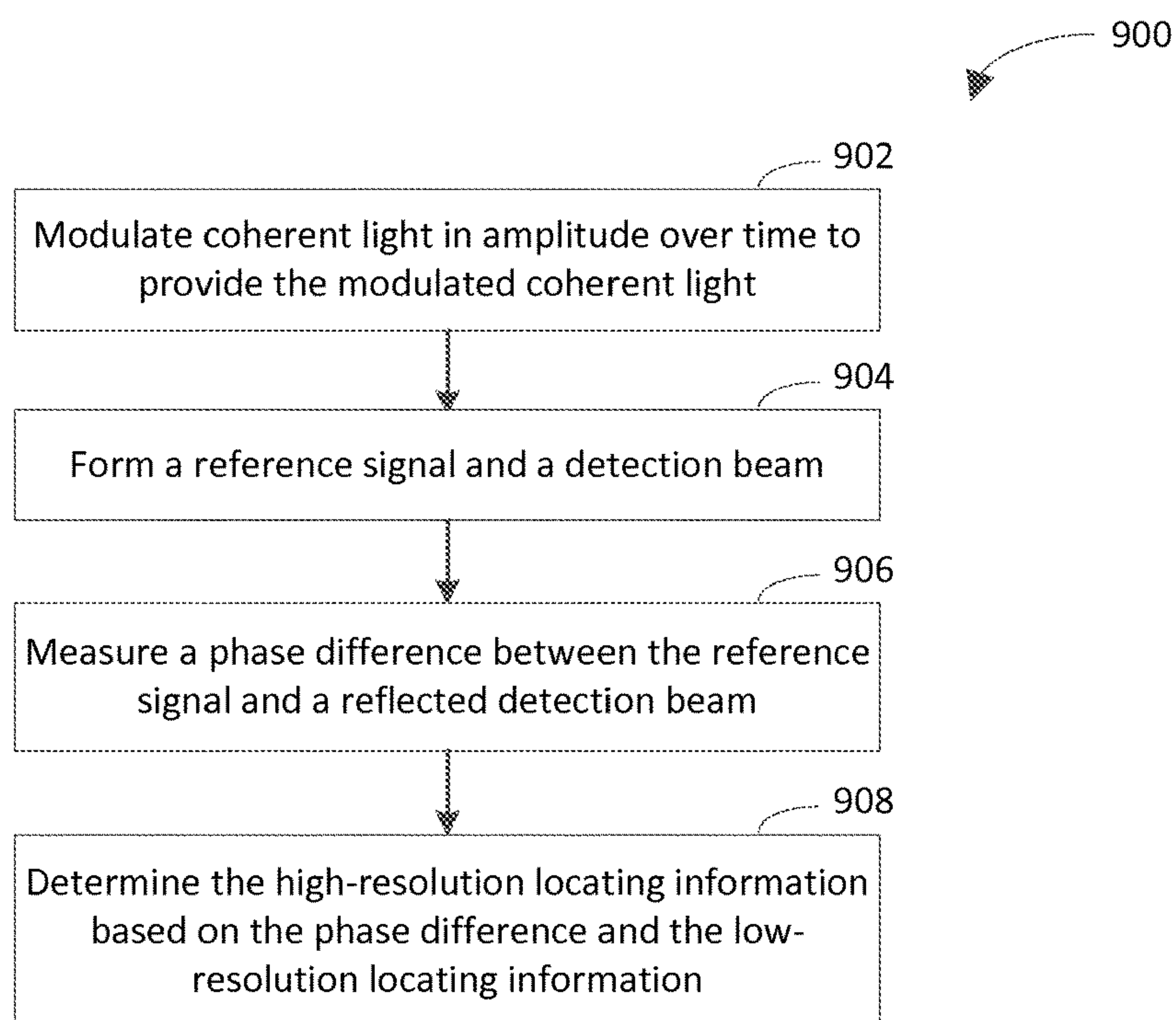


FIG. 9

1000

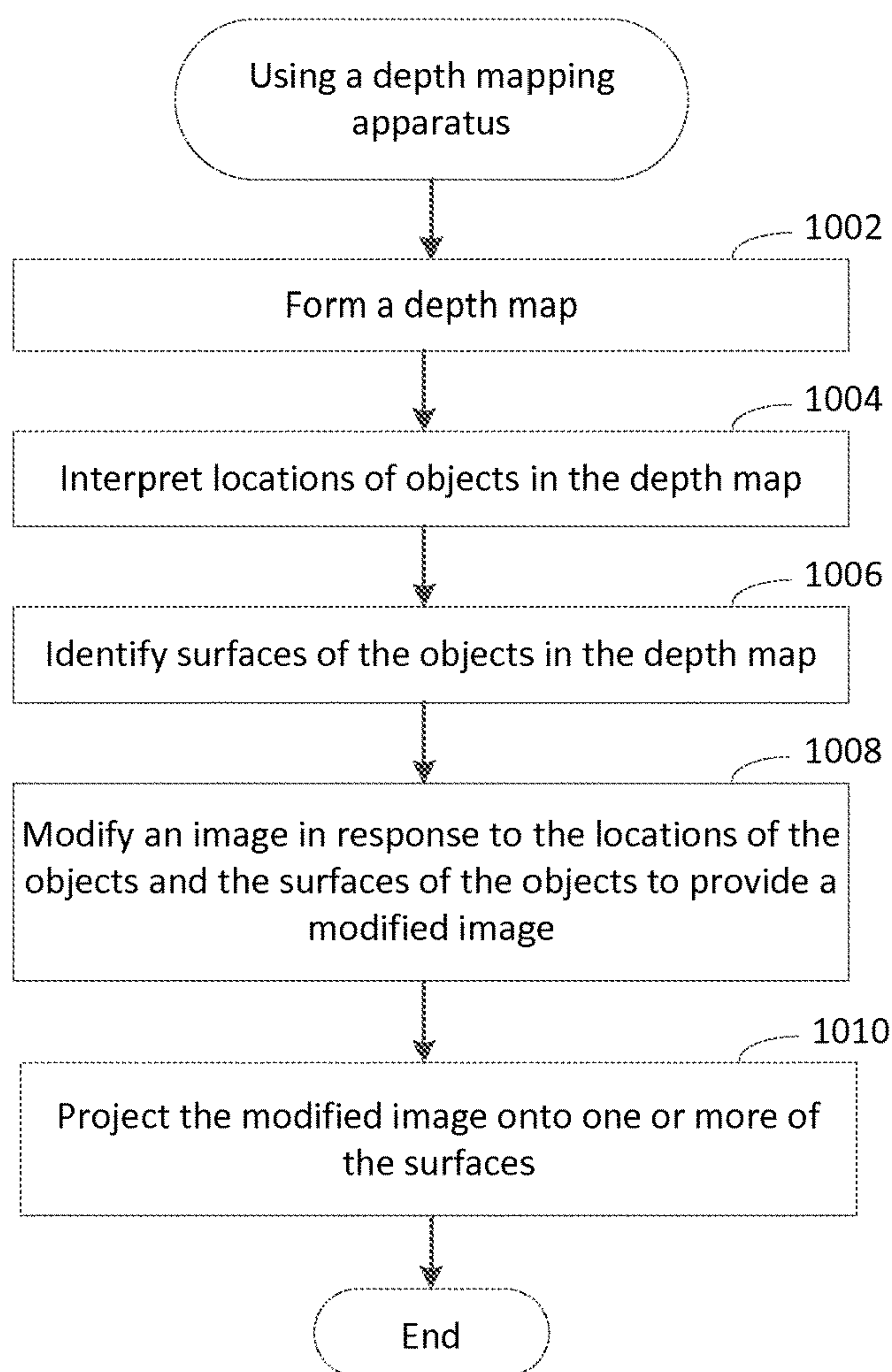


FIG. 10

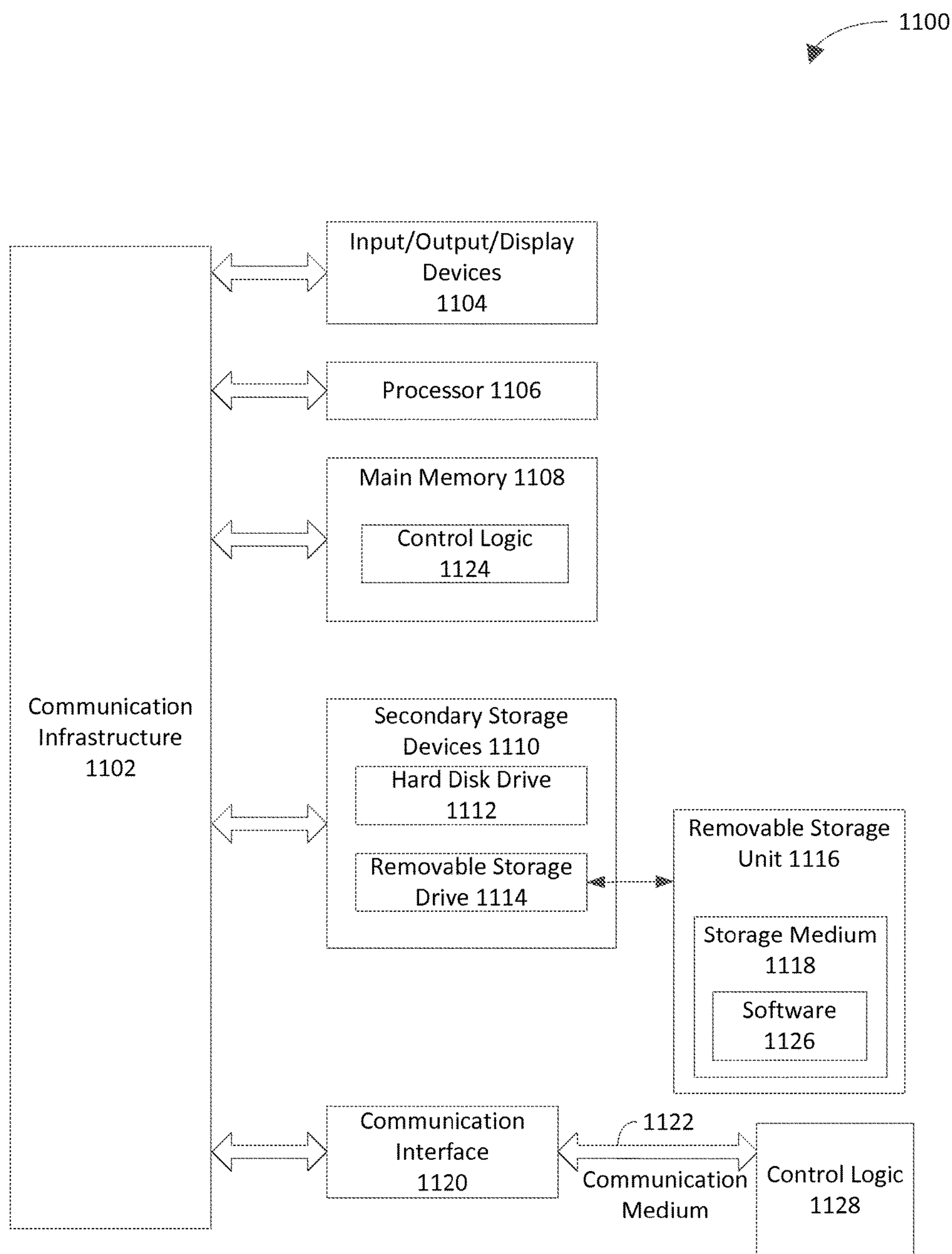


FIG. 11

**PORTABLE PANORAMIC LASER MAPPING
AND/OR PROJECTION SYSTEM**

CROSS-REFERENCE TO RELATED
APPLICATION(S)

This application is a continuation of U.S. patent application Ser. No. 14/747,832, filed Jun. 23, 2015, the entirety of which is incorporated by reference herein.

BACKGROUND

With new developments in areas such as self-driving cars, computer animation, 3D printing, and construction, there is an ever increasing demand for the ability to accurately map an environment (e.g., a person's surroundings) more quickly and/or at lower cost. Lasers are often used to map an environment. However, conventional laser mapping systems typically measure the distance to each point in the environment thousands of times in order to average out noise. Such repetitive measuring may substantially increase an amount of time that is consumed to generate a map and/or a cost associated with generating the map. Moreover, conventional laser mapping systems usually consume a substantial amount of power (e.g., tens of watts) to measure the distances to the points, which are used to generate a map. The relatively high power consumption of such conventional systems may result in a relatively high cost. The relatively high cost and/or time consumption associated with conventional laser mapping systems may render those systems unsuitable for some applications.

SUMMARY

Various approaches are described herein for, among other things, forming a depth map and/or projecting an image onto object(s) based on the depth map. A depth map is a three-dimensional representation of an environment. Forming a depth map may involve scanning a beam of laser light from a central reference location over a grid of points within an environment. For example, at each point within a grid of points, locating information such as distance and velocity is measured. During each measurement, the point being measured is referred to as the current point. Determining distance and/or velocity from the locating information at the current point may utilize a progressive resolution refinement (PRR) technique. In accordance with this example, the locating information may be coordinated with the scan to form the depth map.

An example portable panoramic laser mapping system is described. The portable panoramic laser mapping system includes a depth measurement subsystem, a microelectromechanical systems-based (MEMS-based) scanning subsystem, and a controller. The depth measurement subsystem is configured to measure a distance between a reference location and a current point. The depth measurement subsystem includes a laser source, splitting optics, a light detecting structure, and a signal processing circuit. The laser source is configured to generate coherent light. The coherent light is capable of being modulated. The splitting optics are configured to create a reference beam of light and a detection beam of light from the coherent light. The light detecting structure is configured to convert the reference beam and a reflected detection beam into electrical signals. The reflected detection beam results from reflection of the detection beam from the current point. The signal processing circuit is optionally configured to determine locating information

based on the electrical signals in accordance with a progressive resolution refinement technique. The locating information indicates the distance between the reference location and the current point. The MEMS-based scanning subsystem includes mirror(s) and a light redirecting element that has a microelectromechanical structure. The microelectromechanical structure is configured to perform a scan of the current point within a field of view using the mirror(s). The controller is configured to coordinate the locating information with the scan of the current point over the field of view to form a depth map.

An example method of adapting a pixel size and/or a measurement resolution on a pixel-by-pixel basis is described. In accordance with this method, a laser is used to generate an emission of coherent light. The emission is split into a reference beam of light and a detection beam of light. A scan is performed. The scan comprises a series of distance measurements using the detection beam as the detection beam is scanned over a line or over an area. A range of frequencies and/or a period of time over which the emission is modulated during the scan is altered for a subset of the distance measurements in the scan.

In an aspect of this method, a plurality of operations may be performed for each distance measurement in the scan. For instance, the plurality of operations may include modulating the emission over the range of frequencies and over the period of time. The plurality of operations may include orienting the detection beam toward a point on an object. The plurality of operations may include reflecting the detection beam off of the point on the object to provide a reflected detection beam. The plurality of operations may include combining the reference beam and reflected detection beam on a detector to produce an electrical signal. The electrical signal has a beat frequency. The plurality of operations may include signal processing the electrical signal to determine the beat frequency. The beat frequency is a measurement of a distance to the point on the object.

An example method of performing progressive resolution refinement is described. In accordance with this method, a first measurement with a relatively low resolution is performed using an electrically modulated laser source. The first measurement is processed electrically to determine low-resolution locating information. A second measurement with a relatively high resolution is performed. The second measurement is processed electrically using the low-resolution locating information to enable the processing of the second measurement to determine high-resolution locating information.

This Summary is provided to introduce a selection of concepts in a simplified form that are further described below in the Detailed Description. This Summary is not intended to identify key features or essential features of the claimed subject matter, nor is it intended to be used to limit the scope of the claimed subject matter. Moreover, it is noted that the invention is not limited to the specific embodiments described in the Detailed Description and/or other sections of this document. Such embodiments are presented herein for illustrative purposes only. Additional embodiments will be apparent to persons skilled in the relevant art(s) based on the teachings contained herein.

BRIEF DESCRIPTION OF THE
DRAWINGS/FIGURES

The accompanying drawings, which are incorporated herein and form part of the specification, illustrate embodiments of the present invention and, together with the

description, further serve to explain the principles involved and to enable a person skilled in the relevant art(s) to make and use the disclosed technologies.

FIG. 1 is a block diagram of an example portable panoramic laser mapping and/or projection system in accordance with an embodiment described herein.

FIG. 2 depicts an example implementation of a depth measurement subsystem shown in FIG. 1 in accordance with an embodiment described herein.

FIG. 2a depicts an example implementation of a voltage-controlled oscillator (VCO) architecture in accordance with an embodiment described herein.

FIG. 2b depicts an example implementation of a phase-locked loop (PLL) architecture in accordance with an embodiment described herein.

FIG. 2c depicts an example implementation of an amplitude modulated continuous wave (AMCW) architecture in accordance with an embodiment described herein.

FIG. 3 depicts an example implementation of a microelectromechanical systems-based (MEMS-based) scanning subsystem shown in FIG. 1 in accordance with an embodiment described herein.

FIG. 4 depicts an example implementation of a microelectromechanical structure shown in FIG. 3 in accordance with an embodiment described herein.

FIG. 5 depicts a flowchart of an example method for adapting a pixel size and/or a measurement resolution on a pixel-by-pixel basis in accordance with an embodiment described herein.

FIG. 6 depicts a flowchart of an example method for performing a scan in accordance with an embodiment described herein.

FIGS. 7-9 depict flowcharts of example methods for performing progressive resolution refinement in accordance with embodiments described herein.

FIG. 10 depicts a flowchart of an example method for using a depth mapping apparatus in accordance with an embodiment described herein.

FIG. 11 is a block diagram of a computing system that may be used to implement various embodiments.

The features and advantages of the disclosed technologies will become more apparent from the detailed description set forth below when taken in conjunction with the drawings, in which like reference characters identify corresponding elements throughout. In the drawings, like reference numbers generally indicate identical, functionally similar, and/or structurally similar elements. The drawing in which an element first appears is indicated by the leftmost digit(s) in the corresponding reference number.

DETAILED DESCRIPTION

I. Introduction

The following detailed description refers to the accompanying drawings that illustrate exemplary embodiments of the present invention. However, the scope of the present invention is not limited to these embodiments, but is instead defined by the appended claims. Thus, embodiments beyond those shown in the accompanying drawings, such as modified versions of the illustrated embodiments, may nevertheless be encompassed by the present invention.

References in the specification to “one embodiment,” “an embodiment,” “an example embodiment,” or the like, indicate that the embodiment described may include a particular feature, structure, or characteristic, but every embodiment may not necessarily include the particular feature, structure,

or characteristic. Moreover, such phrases are not necessarily referring to the same embodiment. Furthermore, when a particular feature, structure, or characteristic is described in connection with an embodiment, it is submitted that it is within the knowledge of one skilled in the relevant art(s) to implement such feature, structure, or characteristic in connection with other embodiments whether or not explicitly described.

II. Example Embodiments

Example embodiments described herein are capable of forming a depth map and/or projecting an image onto object(s) based on the depth map. A depth map is a graphical three-dimensional representation of an environment. Forming a depth map may involve scanning a beam of laser light from a central reference location over a grid of points within an environment. For example, at each point within a grid of points, locating information such as distance and velocity is measured. During each measurement, the point being measured is referred to as the current point. Determining distance and or velocity from the locating information at the current point may utilize a progressive resolution refinement (PRR) technique. In accordance with this example, the locating information may be coordinated with the scan to form the depth map.

Example techniques described herein have a variety of benefits as compared to conventional laser mapping techniques and conventional laser projection techniques. For instance, the example mapping techniques may be capable of accurately mapping an environment more quickly and/or at lower cost than conventional laser mapping techniques. As an illustration, the example mapping techniques may take one or two measurements per point in the environment; whereas, conventional techniques may take thousands of measurements per point. The example mapping techniques may reduce an amount of time that is consumed to generate a map and/or a cost associated with generating the map, as compared to conventional laser mapping techniques. The example mapping techniques may require less (e.g., substantially less) laser power output than conventional laser mapping techniques. For example, the example mapping techniques may require less than 1 Watt of laser output power; whereas, the conventional laser mapping techniques may require tens of watts. In an aspect of this example, the example mapping techniques may output less than 1 watt (W) while maintaining a detectable signal at a target distance of at least 200 m, 300 m, 400 m, or 500 m. The example projection techniques may be capable of modifying an image that is to be projected on object(s) in the field of view within a range of 0.1-10 m to compensate for variations in surface(s) of the object(s).

The example portable panoramic laser mapping systems described herein may be characterized by a relatively low manufacturing cost. For instance, the described portable panoramic laser mapping systems may be made using commoditized lasers. The portable panoramic laser mapping systems may combine a depth measurement subsystem, a microelectromechanical systems-based (MEMS-based) scanning subsystem, and a controller into a single portable package. In an example implementation, a laser projection subsystem also may be included in the single portable package. The depth measurement subsystem, the MEMS-based scanning subsystem, and/or the laser projection subsystem may share circuitry, thereby further reducing the manufacturing cost of the described portable panoramic laser mapping systems.

The example portable panoramic laser mapping systems may be usable in more applications than conventional laser mapping systems and conventional laser projection systems. For instance, combining laser mapping functionality (e.g., mapping surroundings) and laser projection functionality (e.g., projecting images overlaid on the mapped surroundings) within a portable panoramic laser mapping system enables the portable panoramic laser mapping system to be used in applications beyond those in which a laser mapping system or a laser projection system alone may be used. For example, the device may be used in a construction application in which images of proposed remodeling designs, hidden facilities, or drill patterns or illumination to install equipment, such as an HVAC aperture, in a structure are overlaid on objects (e.g., walls) inside the structure. In another example, the device may be used to take a relatively detailed 3D scan of a small object (such as a coffee mug) and print meta-information on the object or in a vicinity of the object to indicate how to order another one or more of the object, and further optionally capture feedback from a user via gesture or other detected motion within the device's field of view.

In order to achieve a lowest-cost design point without sacrificing performance, the example techniques described herein may provide improvements in multiple areas, as compared to conventional techniques. For instance, through the use of a progressive resolution refinement technique, the example techniques may reduce complexity and/or cost of signal processing, as compared to conventional techniques. Through the use of flexural-based MEMS systems, the example techniques may achieve a substantially lower scanning cost than conventional techniques. The example techniques may utilize higher-performance MEMS materials to achieve relatively wide scan angles.

FIG. 1 is a block diagram of an example portable panoramic laser mapping and/or projection system 100 (hereinafter "system 100") in accordance with an embodiment described herein. Generally speaking, system 100 operates to perform laser mapping and/or projection. For example, system 100 may perform laser mapping to form a depth map, which is a three-dimensional representation of an environment. In another example, system 100 may perform laser projection to project an image onto object(s) based on such a depth map. It will be recognized that projection (a.k.a. image projection or laser projection) as described herein is a generalization of projecting any visible two-dimensional information, including but not limited to a single still image, multiple still images, video data, and/or partially or fully synthesized visible information (e.g., augmented reality). Detail regarding techniques for performing laser mapping and/or projection is provided in the following discussion.

As shown in FIG. 1, system 100 includes a depth measurement subsystem 102, a microelectromechanical systems-based (MEMS-based) scanning subsystem 104, a laser projection subsystem 106, a controller 108, and a reference fiber optic loop 110. Depth measurement subsystem 102 is configured to measure a distance between a reference location 132 and a current point 134 in a field of view 130. For instance, depth measurement subsystem 102 provides a detection beam 126, which is split from coherent light, to MEMS-based scanning subsystem 104 so that MEMS-based scanning subsystem 104 may provide the detection beam 126 from the reference location 132 to the current point 134. Depth measurement subsystem 102 receives a reflected detection beam 128, which results from reflection of the detection beam 126 from the current point 134 at a surface of an object 112. Depth measurement subsystem 102 com-

pares a representation of the reflected detection beam 128 and a representation of a reference beam, which is split from the coherent light, to determine locating information. The locating information includes a measurement of the distance between the reference location 132 and the current point 134.

Depth measurement subsystem 102 is capable of modulating the coherent light from which the detection beam 126 and the reference beam are split. For example, depth measurement subsystem 102 may modulate the coherent light based on a modulation signal 118 that is received from controller 108. In accordance with this example, the modulation signal 118 may indicate a type of modulation (e.g., amplitude modulation or frequency modulation) to be applied to the coherent light and/or a manner in which such modulation is to be applied (e.g., the amplitudes and/or frequencies to be used). Depth measurement subsystem 102 may provide a measurement signal 122 to controller 108. For instance, the measurement signal 122 may include information regarding the distance between the reference location 132 and the current point 134.

Depth mapping using coherent light can take any of a variety of forms in amplitude and/or frequency modulation techniques. Given the superior noise rejection capability and reduced issues with multiple reflections compared to amplitude modulation techniques, the discussion herein is focused more on frequency modulation techniques. However, it will be recognized that the embodiments described herein may utilize any suitable amplitude and/or frequency modulation techniques. Some example techniques for achieving Frequency Modulated Continuous Wave (FMCW) depth mapping are described in U.S. Pat. No. 4,611,912 to Falk et al. and U.S. Pat. No. 4,830,486 to Goodwin, both of which are incorporated herein by reference in their entireties.

MEMS-based scanning subsystem 104 is configured to scan the current point 134 over the field of view 130. During the scan, MEMS-based scanning subsystem 104 provides the detection beam 126 from the reference location 132 to the current point 134, causing the reflected detection beam 128 to be reflected toward depth measurement subsystem 102. The detection beam 126 travels a distance D before coming into contact with object 112 at the current point 134.

Laser projection subsystem 106 is configured to project an image onto object(s), such as object 112, by raster scanning a beam of modulated laser light typically sourced from the combination of one to three visible laser outputs. U.S. Pat. No. 8,416,482 to Desai et al., the entirety of which is incorporated herein by reference, presents such a projection system. The combined output is referred to as visible light 124. Laser projection subsystem 106 may project the image in response to receiving a modification signal 114 from controller 108. For example, the modification signal 114 may include a modified version of the image. In another example, the modification signal 114 may include attribute(s) and/or instructions for the laser projection subsystem 106 to modify the image prior to projection of the image onto the object(s). For instance, the image may be modified to compensate for variations in distances between the reference location 132 and the surface(s) of the object(s).

Controller 108 is configured to coordinate the locating information with the scan of the current point over the field of view 130 to form a depth map 138. Controller 108 is shown in FIG. 1 to include a store 136 for storing the depth map 138 for illustrative purposes and is not intended to be limiting. It will be recognized that controller 108 need not necessarily include a store 136.

Controller **108** may be further configured to control depth measurement subsystem **102**, MEMS-based scanning subsystem **104**, and/or laser projection subsystem **106**. For instance, controller **108** may control any one or more of the aforementioned subsystems **102**, **104**, and **106** based on measurement **122**. In one example implementation, controller **114** generates the modification signal **114** in response to receipt of measurement **122** from depth measurement subsystem **102**. For example, controller **108** may generate the modification signal **114** to accommodate the distance between the reference location **132** and the current point **134**, as reflected by measurement **122**. In another example implementation, controller **108** controls MEMS-based scanning subsystem **104** using control signal **116**. For instance, controller **108** may use the control signal **116** to control a rate at which MEMS-based scanning subsystem scans the current point **134** over the field of view **130**. In another example implementation, controller **108** controls depth measurement subsystem **102** using progressive resolution refinement control signal **140**. For instance, controller **108** may use the progressive resolution refinement control signal **140** to control the electronic signal processing of the locating information associated with the current point **134**.

Controller **108** may be configured to calibrate depth measurement subsystem **102**. For example, controller **108** may be configured to calibrate depth measurement subsystem **102** using a measurement of the distance from the reference location **132** to a reference object (e.g., object **112**) in the field of view **130**. In accordance with this example, the distance from the reference location **132** to the reference object in the field of view **130** is a known distance. For instance, the distance from the reference location **132** to the reference object may be known prior to the measurement of the distance from the reference location **213** to the reference object being taken.

In another example, controller **108** uses reference fiber optic loop **110** to calibrate depth measurement subsystem **102**. In accordance with this example, controller **108** calibrates depth measurement subsystem **102** using a measurement of the distance through reference fiber optic loop **110**. In further accordance with this example, the distance through reference fiber optic loop **110** is a known distance. For instance, the distance through reference fiber optic loop **110** may be known prior to the measurement of the distance through reference fiber optic loop **110** being taken. The distance through reference fiber optic loop **110** may be measured simultaneously with the measurement of the distance from the reference location **132** to each current point **134** in the field of view **130**, though the scope of the example embodiments is not limited in this respect.

Controller **108** may calibrate depth measurement subsystem **102** once per N measurements of the current point **134** in the field of view **130**, N times per linear scan of the current point **134** in the field of view **130**, N times per scan of the entire field of view **130**, once per N scans of the entire field of view **130**, etc. N is an integer (e.g., a predetermined integer), such as 1, 2, 3, 4, or 5.

In an example embodiment, controller **108** utilizes the depth map **138** to provide a modified image. In accordance with this embodiment, laser projection subsystem **106** is configured to generate the visible light **124** for projecting the modified image onto object(s), such as the object **112**. In an aspect of this embodiment, laser projection subsystem **106** may use a light redirecting element in MEMS-based scanning subsystem **104** that is configured to perform the scan of the current point **134** over the field of view **130** to project the modified image onto the object(s). In another aspect of this

embodiment, MEMS-based scanning subsystem **104** may further include a second light redirecting element, which is different from the light redirecting element configured to perform the scan of the current point **134** over the field of view **130**. In accordance this aspect, laser projection subsystem **106** uses the second light redirecting element in MEMS-based scanning subsystem **104** to project the modified image onto the object(s).

Controller **108** may be configured to determine velocity of at least one point in the field of view **130** based on the locating information. For example, controller **108** may be configured to determine a gesture based on velocities of at least two points in the field of view **130**. In an aspect of this example, controller **108** may determine the gesture based on a relative velocity between the at least two points. Examples of a gesture include but are not limited to a hand being waved and a finger being pointed. Controller **108** may be configured to determine that an object is moving relative to the system **100** and/or a rate at and/or a direction in which an object is moving relative to system **100**.

It will be recognized that system **100** may not include one or more of depth measurement subsystem **102**, MEMS-based scanning subsystem **104**, laser projection subsystem **106**, controller **108**, and/or reference fiber optic loop **110**. Furthermore, system **100** may include components in addition to or in lieu of depth measurement subsystem **102**, MEMS-based scanning subsystem **104**, laser projection subsystem **106**, controller **108**, and/or reference fiber optic loop **110**.

FIG. **2** is a block diagram of an example depth measurement subsystem **200** in accordance with an embodiment described herein. Depth measurement subsystem **200** is an example implementation of a depth measurement subsystem **102** shown in FIG. **1**. Depth measurement subsystem **200** includes a laser source **202**, splitting optics **204**, a light detecting structure **206**, progressive resolution refinement (PRR) circuitry **220**, and a signal processing circuit **210**.

Laser source **202** is configured to generate coherent light **244**. For instance, the coherent light **244** may be an infrared laser with emission wavelengths between 800 nm-2000 nm. In accordance with this example, the infrared laser may have a wavelength of 850 nanometers (nm), 940 nm, 1310 nm, 1550 nm, or any other suitable value. For instance, wavelengths from 1300 to 2000 nm may provide reduced absorption and scattering from dust. The output power of laser source **202** may be less than 100 milliwatts (mW) for mapping regions of 10 m or less. For regions in excess of 10 m, higher powers may be needed to achieve sufficiently high reflected signals for determining locating information.

Laser source **202** is capable of modulating the coherent light **244**. For instance, laser source **202** may modulate the coherent light **244** in frequency and/or amplitude. Laser source **202** may modulate the coherent light **244** in response to (e.g., based on) receipt of the modulation signal **118**, though the scope of the example embodiments is not limited in this respect. By modulating a current supply to laser source **202**, the wavelengths of the coherent light **244** can be swept anywhere from thousandths of a nanometer to multiple nanometers. The sweep in wavelength can produce large changes in the optical emission frequency. As an example, tenths of a nanometer corresponds to several gigahertz (GHz) changes in optical emission frequency.

In the case of frequency modulation, the modulation signal **118** may be swept over a linear saw-tooth profile with a period in a range of 5 nanoseconds (ns) to 500 milliseconds (ms). Frequency modulation changes in a range of 150 MHz

to 150 GHz may be utilized depending on the speed and range resolution that are needed.

There are many ways to modulate amplitude and/or frequency of a laser's emission. For that reason, we refer to the combination of the laser and the modulator as the laser source **202** herein for the purpose of discussion. An example for frequency modulation would be a distributed feedback laser (DFB) diode laser powered by a current source. By linearly ramping the current source output in time, the frequency of the laser's emission can be linearly modulated. Varying the temperature of a diode laser is yet another way to modulate a diode laser's emission frequency, though it may not be well suited for the time constants associated with depth mapping. An example for amplitude modulation would be a diode laser followed by an optical chopper.

Splitting optics **204** are configured to create a reference beam **246** of light and the detection beam **126** of light from the coherent light **244**. For instance, splitting optics **204** may collimate and optically split the coherent light **244** to create the reference beam **246** and the detection beam **126**. Accordingly, splitting optics **204** may include collimation optics, a splitter to split the coherent light **244**, and one or more polarizing filters for altering the detection beam **126** and/or the reference beam **246** for proper interaction between the reflected detection beam **128** and the reference beam **246** at a surface of light detecting structure **206**.

Light detecting structure **206** is configured to convert the reference beam **246** and the reflected detection beam **128** into electrical signals. The reflected detection beam **128** results from reflection of the detection beam **126** from the current point **134**, as shown in FIG. 1. The electrical signals may include a beat signal **248**. For instance, when the reference beam **246** and the reflected detection beam **128** combine at light detecting structure **206**, the beat signal **248** is produced. The beat signal **248** is an electrical result of optical mixing of the reference beam **246** and the reflected detection beam **128** at a surface of light detecting structure **206**.

In an example embodiment, depth measurement subsystem **200** is configured to perform Frequency Modulated Continuous Wave (FMCW) depth mapping with a linear ramp in frequency over an interval Δf , referred to as a chirp frequency excursion. In accordance with this embodiment, the beat signal **248** has a beat frequency, which represents a measurement of the distance between the reference location **132** and the current point **134**. The beat frequency is directly proportional to the distance D traveled by the detection beam **126**, as shown in FIG. 1, in accordance with the following equation:

$$f_{beat} = 2 \left(\frac{D * \Delta f}{c * T} \right) \quad (\text{Equation 1})$$

where D is the distance from the reference location **132** to the current point **134**; c is the speed of light; and T is the duration of the linear frequency ramp (i.e., "chirp period").

FMCW signals facilitate the determination of both the distance between the reference location **132** and each current point **134** in the field of view **130**, and the speed of a point in the field of view **130** as it moves relative to the reference location **132** due to the Doppler effect. To carry out both distance and speed measurements, a saw-tooth profile with rising and falling linear ramps in frequency may be used. Two beat frequencies may be created whose average and difference can be used to compute both relative speed (e.g.,

velocity) of an object (e.g., object **112**) and distance to the object. FMCW allows ranging with resolution proportional to the bandwidth ($\Delta f / \Delta T$) within the pulse window, allowing range to be determined with a single pulse per point in the field of view **130**.

Light detecting structure **206** may be configured in many ways. For example, light detecting structure **206** may be mounted adjacent to MEMS-based scanning subsystem **104** and may receive light from the field of view **130**. In another example, light detecting structure **206** may be positioned in the optical path of splitting optics **204** and may receive only light from the field of view **14** that passes back through MEMS-based scanning subsystem **104**. In yet another example, light detecting structure **206** may be integrated onto MEMS-based scanning subsystem **104** as part of a composite mirror system through a layer transfer process. In accordance with this example, the medium of light detecting structure **206**, which may be specially designed, may be bonded to MEMS-based scanning subsystem **104** for both mechanical and electrical connection.

Light detecting structure **206** may be made out of any of a variety of types of devices, depending on the application and the wavelengths of the coherent light **244** being used for depth measurement. Example devices that may be used to make light detecting structure **206** include but are not limited to an avalanche photodiode, a Metal-Semiconductor-Metal Schottky photodiode, a photoconductive switch, and an ultra-fast p-i-n photodiode.

Equation 1 reveals the proportional relationship between the chirp frequency excursion and the beat frequency. As an example, consider the case of a 10 m distance, a 20 GHz chip range, and a chirp duration of 1 microseconds (μs). This set of conditions would produce a 1.33 GHz beat frequency. Although it is possible to measure such a frequency, electronics used to process signals below 500 MHz typically are much less expensive. To reduce the signal processing requirements, one could reduce the chirp frequency excursion to 2 GHz; however, there is a resulting penalty in range resolution according the following equation:

$$\delta R = \frac{c}{2 * \Delta f} \quad (\text{Equation 2})$$

where δR is the range resolution; Δf is the chirp frequency excursion; and c is the speed of light. It can be seen from Equation 2 that a 10x reduction in chirp frequency excursion results in a 10x increase in the minimum range resolution. If in the example above, the chirp frequency excursion were decreased to 2 GHz, the resulting beat frequency would be decreased to 133 MHz; however, the range resolution would be negatively impacted by a factor of 10. The progressive resolution refinement technique was designed to achieve the higher range resolution depth maps, but at a substantially lower cost and/or complexity of system **100**.

A progressive resolution refinement technique is a technique in which a first (e.g., relatively lower-resolution) measurement is determined, and a second (e.g., relatively higher-resolution) measurement is determined utilizing the first measurement. By utilizing the first measurement to perform the second measurement, the cost and/or complexity of system **100** may be substantially lowered.

For example, in one embodiment of progressive resolution refinement, a first measurement may be performed where modulation signal **118** modulates laser source **202** to produce a 2 GHz chirp frequency excursion, which as shown

in the prior example, results in a beat signal **248** having a 133 MHz beat frequency for an example current point with a 10 m distance from the reference location **132**. Processing of the locating information from the beat signal **248** starts with progressive resolution refinement block **220** shown in FIG. **2**, and detailed in FIG. **2a**. Referring to FIG. **2a**, for the first measurement, switch **261** would be opened and switch **262** would be closed in order to bypass high frequency signal mixer **240** and feed directly into signal processing circuit **210**. Signal processing circuit **210** may include element **241**, which includes an analog-to-digital conversion circuit coupled with a digital-signal-processing (i.e., DSP) block that carries out a fast Fourier transform (i.e., FFT), to determine the value of the beat frequency in the beat signal **248**. In another embodiment, signal processing circuit **210** may include a phased-locked loop (i.e., PLL) circuit **242** to determine a measure of the beat frequency in the beat signal **248**, a measure being the voltage required to lock the phased locked-loop's internal voltage controlled oscillator on the beat frequency. It will be recognized that depth measurement subsystem **200** need not necessarily include element **241** and/or PLL circuit **242**.

A second measurement using the progressive resolution refinement technique may be performed where modulation signal **118** modulates laser source **202** to produce a 20 GHz chirp frequency excursion, which as shown in the prior example, results in a beat signal **248** having a 1.33 GHz beat frequency for an example current point with a 10 m distance from the reference location **132**. In this second measurement, switch **261** would be closed and switch **262** would be opened in order to send the beat signal with the higher beat frequency through high frequency signal mixer **240**. Based on the results of the first measurement, controller **108** may send progressive resolution refinement control signal **140** to select a voltage-controlled oscillator (VCO) signal **263** from a VCO clock tree **264**. When VCO signal **263** is mixed with beat signal **248** using high frequency signal mixer **240**, low frequency beat signal **250** results. Low pass filter (i.e. LPF) **290** is used to filter out other signal products of signal mixer **240** not related to the low frequency beat signal **250**. Low frequency beat signal **250** has a beat difference frequency equal to the difference between the frequency of the VCO signal **263** and the beat frequency of the beat signal **248**. Beat difference frequency of low frequency beat signal **250** is a measure of the distance to the current point **134**. Signal processing circuit **210** may be used to construct measurement **122** from the beat difference frequency of low frequency beat signal **250**. For example, signal processing circuit **210** may use the aforementioned PLL or FFT circuits to determine the value of the beat difference frequency of low frequency beat signal **250**.

VCO clock tree **264** may include a progression of VCO clock signals, wherein the difference in frequency between any two successive VCO clock signals are within the signal processing capabilities of signal processing circuitry **210**. Based on the results of the first measurement, controller **108** may have sufficient information to predict the expected beat frequency of beat signal **250** during the second measurement and thereby select the appropriate VCO clock signal **263** to produce low frequency beat signal **250** that is within the signal processing capabilities of signal processing circuitry **210**.

The same process may be used for all the other pixels within the field of view. For example, the locating information for each pixel may be determined in a first (e.g., relatively lower-resolution) measurement to bin the approximate distance for each pixel and then using the approximate

distance from the first measurement, perform a second (e.g., relatively high-resolution) measurement to obtain more accurate and/or precise locating information.

In another embodiment of progressive resolution refinement, the phased locked loop architecture **270** shown in FIG. **2b** is used. Referring to FIG. **2b**, in order to determine locating information from the beat signal **248**, the beat signal **248** is fed into a PLL circuit **271**. Controller **108** may send progressive resolution refinement control signal **140** to PLL circuit **271** in order to set the center frequency of the phased locked loop such that the PLL circuit **271** can lock on the beat frequency of the beat signal **248**. Without high expense or complexity, for a single fixed center frequency, it is unlikely that PLL circuit **271** could be designed to span relatively high and relatively low resolution measurements over ranges of 50 m, 100 m, 200 m, 300 m, 400 m, or 500 m. In such examples, beat frequencies may need to be measurable from 10 MHz to 50 GHz. High frequency PLL circuits exist, but the range of frequencies over which the PLL can rapidly lock is typically limited. In an example embodiment of progressive resolution refinement, the phased locked loop architecture **270** does not need to span the entire range.

For example, a first measurement may be performed with a relatively low resolution where the modulation signal **118** modulates laser source **202** to produce a 2 GHz chirp frequency excursion, which as shown before, results in a beat signal **248** having a 133 MHz beat frequency for an example current point with a 10 m distance from the reference location **132**. Processing of the locating information from the beat signal **248** starts with the progressive resolution refinement block **220** detailed in FIG. **2b**. For the first measurement, controller **108** may provide a progressive resolution refinement control signal **140** to PLL circuit **271** to set a low center frequency thereby enabling PLL circuit **271** to lock onto relatively low beat frequency of the beat signal **248**. Signal processing circuit **210** may include an analog-to-digital conversion circuit to measure the control voltage for the voltage controlled oscillator within PLL circuit **271**, the control voltage being a measure of the beat frequency of the beat signal **248**. Furthermore, the beat frequency provides a measure of the distance to the current point **134**.

A second measurement using the progressive resolution refinement technique may be performed where modulation signal **118** modulates laser source **202** to produce a 20 GHz chirp frequency excursion, which as shown in the prior example, results in a beat signal **248** having a 1.33 GHz beat frequency for an example current point with a 10 m distance from the reference location **132**. Based on the results of the first measurement, controller **108** may have sufficient information to predict the expected beat frequency of the low frequency beat signal **250** during the second measurement and thereby select the appropriate PLL center frequency for PLL circuit **271** to enable it to lock on to the beat frequency of the beat signal **248**. Controller **108** may set the appropriate PLL center frequency for PLL circuit **271** using the progressive resolution refinement control signal **140**. Signal processing circuit **210** may include an analog-to-digital conversion circuit to measure the control voltage for the voltage controlled oscillator within PLL circuit **271**, the control voltage being a measure of the beat frequency of the beat signal **248**. Signal processing circuit **210** may be used to construct measurement **122** from the measure of the beat frequency of the beat signal **248**.

It will be recognized that depth measurement subsystem **200** need not necessarily include VCO clock tree **264**, signal

mixer **240**, and/or phased locked loop architecture **270** to enable the progressive resolution refinement technique. Other circuit topologies to accomplish the measurement task are possible and known to those skilled in the art of circuit design. Furthermore, the first measurement need not be a measurement of the current point **134**. Instead, the first measurement may be an estimate of the distance from the reference location **132** to the current point **134** based on measurements of one or more other points within the field of view (e.g., another point that is adjacent to the current point **134**).

In an example progressive resolution refinement technique embodiment, the first measurement of the distance between the reference location **132** and the current point **134** is used to narrow a frequency range over which the beat frequency is to be searched in the second measurement by more than a factor of two. For example, in one embodiment, if a relatively high resolution second measurement produces a beat frequency of a beat signal **248** of 2.5 GHz, VCO architecture **259** shown in FIG. **2a** may produce a low frequency beat signal **250** with a difference beat frequency of 500 MHz, 500 MHz being more than a factor of two reduction from the original 2.5 GHz beat frequency. In another embodiment, for example, if a relatively high resolution second measurement produces a beat frequency of a beat signal **248** of 2.5 GHz, PLL circuit **271** shown in FIG. **2b** may be controlled by progressive resolution refinement signal **140** to have a center frequency near 2.5 GHz. Furthermore, PLL circuit **271** may have a frequency lock range of 500 MHz, 500 MHz being a range of frequencies more than a factor of two reduction from the original 2.5 GHz beat frequency.

In an aspect of this embodiment, laser source **202** shown in FIG. **2** is configured to perform a periodic chirp in which the coherent light **244** is modulated (e.g., linearly) in frequency over a chirp period of time and over a chirp frequency excursion. In accordance with this aspect, controller **108** may be configured to adjust the chirp frequency excursion to adapt resolution of the locating information. Controller **108** may be configured to adapt the resolution for a single point within a scan, a subset of the points within a scan, or all of the points within a scan.

In one example of this implementation, the current point **134** has a pixel size, which is a distance over which the current point **134** scans during the chirp period. In the MEMS-based scanning subsystem **104** described above with reference to FIG. **1**, one or more of the axes may be driven at mechanical resonance. Accordingly, if a constant chirp period were used, the effective pixel size may vary throughout the scan due to the sinusoidal motion of the microelectromechanical structure therein. One technique for rectifying this issue is to adapt the chirp period to the angular velocity of the microelectromechanical structure to maintain a constant pixel size or a specified pixel size. According to Equation 1, as a secondary result, the beat frequency of the beat signal **240** will be modified as the chirp period is modified. In accordance with this technique, the progressive range resolution circuitry in VCO architecture **259** shown in FIG. **2a** could accommodate this chirp period modification by stretching or compressing the base VCO within the VCO clock tree **264**. In doing so, each VCO signal **263** selected would accommodate a constant range of distances despite varying chirp periods.

Other frequency modulation schemes may be used, in addition to or in lieu of the FMCW scheme described above. For instance, Amplitude Modulated Continuous Wave

(AMCW) is another scheme in which laser modulation can be utilized to determine both the relative speed of an object and distance to the object.

In AMCW, one or more simultaneous carrier signals in the form of fundamental sinusoidal modulation or pulse trains are emitted by laser source **202**. The modulation frequencies are chosen based on an unambiguous range to the object. Multiple frequencies of varying amplitude ratios may be emitted either simultaneously or in a predefined sequence to facilitate enhanced range resolution and determination of relative reflectivity of surfaces of the object.

In an embodiment of the AMCW technique, in accordance with the progressive resolution refinement technique, for a first measurement of each point in the entire field of view **130**, each point may first be scanned using a modulation frequency chosen as the maximum frequency for the maximum unambiguous range for which the system is configured to operate. Locating information from this first measurement will necessarily be of lower resolution; however, using the locating information from the first measurement, a second measurement may employ different modulation frequencies either emitted simultaneously or in a predefined sequence to obtain a relatively higher resolution measurement.

In both the first measurement and the second measurement, the distance to a given point in the field of view **130** may be given by the instantaneous phase angle of a demodulated representation of the reflected detection beam. Demodulation and determination of the instantaneous phase angle may be accomplished through digital signal processing or through analog homodyne mixing in an I/Q detector.

For example, FIG. **2c** shows an AMCW architecture **259** in accordance with the progressive resolution refinement technique. As shown in FIG. **2c**, multiple changes to system **100** are made to accommodate AMCW compared to FMCW, including but not limited to reference beam **248** becomes reference signal **248A**, which is an electrical representation of the amplitude modulation signal; only reflected detection beam **128** impinges upon light detecting structure **206**; and beat signal **248** becomes amplitude signal **248B**.

Internal to the AMCW architecture **259** is an I/Q detector. Reference signal **248A** provides the reference for multipliers **282** and **283**. After multipliers **282** and **283**, low pass filter (i.e. LPF) **292** and LPF **293** pass the low frequency phase information. On one leg of the I/Q detector, phase delay **281** is used to provide the quadrature signal reference to multiplier **282**. Analog-to-digital converter (i.e., ADC) **284** and ADC **285** digitize the analog signals and provide Q-Data **286** and I-Data **287**, respectively. From Q-Data **286** and I-Data **287**, digital signal processor (DSP) **288** is able to compute the relative phase between the reference signal **248A** and the reflected detection beam **128**, the relative phase being a measure of the distance to the current point **134**. DSP **288** utilizes the first measurement and the second measurement in order to determine the relatively high-resolution locating information contained within measurement **122**.

AMCW architecture **259** is shown to include an I/Q detector for illustrative purposes and is not intended to be limiting. It will be recognized that there are a variety of techniques for determining the phase of an AMCW signal.

FIG. **3** is a block diagram of an example microelectromechanical systems-based (MEMS-based) scanning subsystem **300** in accordance with an embodiment described herein. MEMS-based scanning subsystem **300** is an example implementation of a MEMS-based scanning subsystem **104** shown in FIG. **1**. MEMS-based scanning subsystem **300** includes a light redirecting element **302** and mirror(s) **304**.

Light redirecting element **302** has a microelectromechanical structure **306** that is configured to perform a scan **352** of the current point **134** over the field of view **130** using the mirror(s) **304**. For instance, microelectromechanical structure **306** may perform the scan **352** in response to receipt of the control signal **116**. Mirror(s) are configured to reflect the detection beam **126** from the reference location **132** to the current point **134** during the scan **352**.

The visible light **124** may define an image that is to be projected onto object(s). Microelectromechanical structure **306** may be configured to project the visible light **124** onto the object(s) using the mirror(s) **304**. For instance, microelectromechanical structure **306** may project the visible light **124** onto the object(s) in response to receipt of the control signal **116**.

In the presence of moving objects, a Doppler shift may induce a frequency shift in the beat signal that is ambiguous with range determination in the case of a linearly increasing chirp. Rising and falling chirps may be used to cause respective beat frequencies, which may be used to compute both velocity and depth of points in the field of view **130**. The average of the beat frequencies represents the distance **D** between the reference location **132** and the current pixel **134**, and the difference between the beat frequencies represents the relative velocity between the points.

FIG. **4** is a block diagram of an example microelectromechanical structure **400** in accordance with an embodiment described herein. Microelectromechanical structure **400** is an example implementation of a microelectromechanical structure **306** shown in FIG. **3** in accordance with an embodiment. Microelectromechanical structure **400** includes a frame **402**, a first inner flexure **404a**, a second inner flexure **404b**, a first outer flexure **406a**, a second outer flexure **406b**, a first frame sensing electrode **408a**, a second frame sensing electrode **408b**, a first mirror sensing electrode **410a**, a second mirror sensing electrode **410b**, and mirror(s) **412**.

Frame **402** provides structural support for inner flexures **404a-404b** and mirror(s) **412**.

Inner flexures **404a-404b** and outer flexures **406a-406b** are configured to mount mirror(s) **412**. For instance, inner flexures **404a-404b** are shown to directly mount mirror(s) **412** via direct contact with mirror(s) **412**, and outer flexures **406a-406b** are shown to indirectly mount mirror(s) **412** via indirect contact with mirror(s) **412**, though the scope of the example embodiments is not limited in this respect. Inner flexures **404a-404b** mechanically couple frame **402** to mirror(s) **412**. Inner flexures **404a-404b** enable mirror(s) **412** to rotate about axis **414**, as depicted by arrow **420**. Outer flexures **406a-406b** mechanically couple frame **402** to a substrate **422**. Outer flexures **406a-406b** enable frame **402** to rotate about axis **416**, as depicted by arrow **418**.

Mirror(s) **412** is configured to reflect light (e.g., coherent light) that is incident on mirror(s) **412**. The direction in which the light is reflected is based on an extent to which mirror(s) **412** is rotated about axis **414** and an extent to which frame **402** is rotated about axis **416**.

Frame sensing electrodes **408a-408b** are configured to sense motion of frame **402**. For instance, frame sensing electrodes **408a-408b** may be configured to sense an extent to which frame **402** rotates clockwise or counterclockwise about the axis **416**.

Mirror sensing electrodes **410a-410b** are configured to sense motion of mirror(s) **412**. For instance, mirror sensing electrodes **410a-410b** may be configured to sense an extent to which mirror(s) **412** are rotated clockwise or counterclockwise about the axis **414**.

In an example embodiment, inner flexures **404a-404b** and outer flexures **406a-406b** are used in lieu of spinning elements to mount mirror(s) **412**. Accordingly, microelectromechanical structure **400** may not include spinning elements.

In another example embodiment, inner flexures **404a-404b** and/or outer flexures **406a-406b** are formed from one or more materials having a fracture toughness of at least 15 MPa ($m^{1/2}$) and a Young's modulus of at least 10 GPa. MPa represents megapascals; GPa represents gigapascals; and m represents meters.

In yet another example embodiment, inner flexures **404a-404b** and/or outer flexures **406a-406b** are formed from one or more materials capable of undergoing a strain of two percent without failure.

In still another example embodiment, mirror(s) **412** are formed on a substrate material that is different from a material from which inner flexures **404a-404b** and/or outer flexures **406a-406b** are formed.

In yet another example embodiment, microelectromechanical structure **400** is configured to pivot at least one mirror (e.g., at least one of mirror(s) **412**) about one or more axes (e.g., axis **414** and/or axis **416**) over an optical field of view greater than a threshold angle. For instance, the threshold angle may be 60 degrees, 70 degrees, 80 degrees, or 90 degrees.

In still another example embodiment, microelectromechanical structure **400** is configured to pivot at least one mirror (e.g., at least one of mirror(s) **412**) about one or more axes (e.g., axis **414** and/or axis **416**) at a frequency greater than a threshold frequency. For instance, the threshold frequency may be 400 Hz, 500 Hz, 600 Hz, 800 Hz, or 1 kHz.

Microelectromechanical structure **400** may be configured using a 2-axis mirror system, as shown in FIG. **4**, or using a pair of single axis mirrors. Selection of the appropriate configuration is based on the application requirements. A 2-axis system may be lower in cost given the reduced assembly requirements; however, a pair of single-axis mirrors may be desirable for a higher performance system given the mirror size and drive frequency requirements.

Microelectromechanical structure **400** may be made from silicon (as are most MEMS structures). However, depending on the application requirements which may include large mirrors, higher scan frequencies, and relatively large fields-of-view, higher performance materials such as alloyed titanium may be used in addition to or in lieu of silicon. In one example, if a titanium alloy is used to make inner flexures **404a-404b** and/or outer flexures **406a-406b**, the same sheet of material may be used for forming mirror(s) **412**. Such material may be polished and coated with a second material to increase reflectivity. In another example, if the application's mirror flatness requirements are relatively high, mirror **412** may be formed on a different substrate than inner flexures **404a-404b** and outer flexures **406a-406b** and later bonded to inner flexures **404a-404b**. One example would be a metal coated piece of silicon bonded to the titanium alloy using a eutectic bond.

A field-of-view of 60 degrees implies a peak-to-peak mechanical deflection of 30 degrees. Given the reflection off of a mirror substrate, the optical field of view is twice the mechanical deflection. Peak deflections of greater than 15 degrees are formidable to achieve using MEMS, especially as the frequency requirements exceed 1 kHz.

Actuation of microelectromechanical structure **400** could take many forms including electrostatic, Lorentz, or piezoelectric based forcing. For a 2-axis microelectromechanical structure fabricated from silicon, electrostatic actuation may

be used given the ease of fabrication, though the scope of the example embodiments is not limited in this respect. U.S. Pat. No. 6,753,638 to Adams et al., the entirety of which is incorporated herein by reference, presents such a 2-axis electrostatically actuated mirror system.

The same actuators that were used to drive microelectromechanical structure **400** may be used for sensing the motion of microelectromechanical structure **400**. For instance, frame sensing electrodes **408a** and **408b** and/or mirror sensing electrodes **410a** and **410b** may be used. Frame sensing electrodes **408a** and **408b** may be mounted to the floor below frame **402**. Assuming frame **402** is made of a conductive material, a carrier signal of approximately 100 kHz and 1 volt peak may be applied to frame **402**. Frame sensing electrodes **408a** and **408b** may be connected to a differential input trans-impedance amplifier and demodulation circuitry, which are known in the MEMS industry, for sensing the motion of frame **402**.

Other example techniques for sensing the motion include optical, Lorentz, piezoelectric, and capacitance-based techniques. For instance, capacitance-based techniques may be relatively simple and have a relatively lower temperature dependence than some other techniques.

FIG. **5** depicts a flowchart **500** of an example method for adapting a pixel size and/or a measurement resolution on a pixel-by-pixel basis in accordance with an embodiment described herein. For illustrative purposes, flowchart **500** is described with respect to system **100** shown in FIG. **1** and depth measurement subsystem **200** shown in FIG. **2**. Further structural and operational embodiments will be apparent to persons skilled in the relevant art(s) based on the discussion regarding flowchart **500**.

As shown in FIG. **5**, the method of flowchart **500** begins at step **502**. In step **502**, a laser is used to generate an emission of coherent light. In an example implementation, laser source **202** uses a laser to generate an emission of coherent light **244**.

At step **504**, the emission is split into a reference beam of light and a detection beam of light. In an example implementation, splitting optics **204** split the emission into a reference beam **246** of light and a detection beam **126** of light.

At step **506**, a scan is performed. The scan comprises a series of distance measurements using the detection beam as the detection beam is scanned over a line or over an area. In an example implementation, MEMS-based scanning subsystem **104** performs the scan. In accordance with this implementation, the scan comprises a series of distance measurements using the detection beam **126** as the detection beam **126** is scanned over a line or over an area.

At step **508**, a range of frequencies and/or a period of time over which the emission is modulated during the scan are altered for a subset of the distance measurements in the scan. In an example implementation, laser source **202** alters the range of frequencies and/or the period of time over which the emission is modulated during the scan for the subset of the distance measurements in the scan.

In accordance with the embodiment of FIG. **5**, the pixel size is a distance over which the detection beam is scanned during a measurement.

In some example embodiments, one or more steps **502**, **504**, **506**, and/or **508** of flowchart **500** may not be performed. Moreover, steps in addition to or in lieu of steps **502**, **504**, **506**, and/or **508** may be performed. For instance, in an example embodiment, the method of flowchart **500** further includes altering the period of time to obtain a specified pixel size at each measurement in a scan. In an

aspect of this embodiment, the specified pixel size is a constant pixel size over an entirety of the scan. In an implementation of this aspect, altering the period of time to obtain the specified pixel size at each measurement comprises altering a primary clock of a VCO clock tree within a VCO architecture to enable the signal processing architecture to track a change in the pixel size at each measurement.

In another example embodiment, the method of flowchart **500** further includes altering the range of frequencies to obtain a specified measurement resolution at each measurement in a scan.

FIG. **6** depicts a flowchart **600** of an example method for performing a scan in accordance with an embodiment described herein. Flowchart **600** is described as an example implementation of step **506** shown in FIG. **5** for purposes of illustration. For instance, the steps of flowchart **600** may be performed for each distance measurement in the scan. For illustrative purposes, flowchart **600** is described with respect to system **100** shown in FIG. **1** and depth measurement subsystem **200** shown in FIG. **2**. Further structural and operational embodiments will be apparent to persons skilled in the relevant art(s) based on the discussion regarding flowchart **600**.

As shown in FIG. **6**, the method of flowchart **600** begins at step **602**. In step **602**, the emission is modulated over the range of frequencies and over the period of time. In an example implementation, laser source **202** modulates the emission over the range of frequencies and over the period of time.

At step **604**, the detection beam is oriented toward a point on an object. In an example implementation, MEMS-based scanning subsystem **104** orients the detection beam **126** toward a current point **134** on an object **112**.

At step **606**, the detection beam is reflected off of the point on the object to provide a reflected detection beam. In an example implementation, MEMS-based scanning subsystem **104** reflects the detection beam **126** off of the current point **134** on the object **112** to provide a reflected detection beam **128**.

At step **608**, the reference beam and reflected detection beam are combined on a detector to produce an electrical signal. The electrical signal has a beat frequency. In an example implementation, light detecting structure **206** combines the reference beam **246** and the reflected detection beam **128** thereon to produce beat signal **248**. In accordance with this implementation, the beat signal **248** has the beat frequency.

At step **610**, the electrical signal is signal processed to determine the beat frequency. The beat frequency is a measurement of a distance to the point on the object. In an example implementation, signal processing circuit **210** signal processes the beat signal **248** to determine the beat frequency. In accordance with this implementation, the beat frequency is a measurement of a distance to the current point **134** on the object **112**.

In some example embodiments, one or more steps **602**, **604**, **606**, **608**, and/or **610** of flowchart **600** may not be performed. Moreover, steps in addition to or in lieu of steps **602**, **604**, **606**, **608**, and/or **610** may be performed.

FIGS. **7-9** depict flowcharts **700** and **800** of example methods for performing progressive resolution refinement in accordance with embodiments described herein. FIG. **10** depicts a flowchart **1000** of an example method for using a depth mapping apparatus in accordance with an embodiment described herein. For illustrative purposes, flowcharts **700**, **800**, **900**, and **1000** are described with respect to system **100**

shown in FIG. 1 and depth measurement subsystem 200 shown in FIG. 2. Further structural and operational embodiments will be apparent to persons skilled in the relevant art(s) based on the discussion regarding flowcharts 700, 800, 900, and 1000.

As shown in FIG. 7, the method of flowchart 700 begins at step 702. In step 702, a first measurement with a relatively low resolution is performed using modulated coherent light. In an example implementation, depth measurement subsystem 102 performs the first measurement with the relatively low resolution using the modulated coherent light.

At step 704, the first measurement is processed electrically to determine low-resolution locating information. The low-resolution locating information includes a relatively low resolution estimate of a distance between a reference location and a current point. In an example implementation, signal processing circuit 210 processes the first measurement electrically to determine the low-resolution locating information. In accordance with this embodiment, the low-resolution locating information includes a relatively low resolution estimate of the distance between the reference location 132 and the current point 134.

At step 706, a second measurement with a relatively high resolution is performed. In an example implementation, depth measurement subsystem 102 performs the second measurement with the relatively high resolution.

At step 708, the second measurement is processed electrically using the low-resolution locating information to enable the processing of the second measurement to determine high-resolution locating information. The high-resolution locating information includes a relatively high resolution estimate of the distance between the reference location and the current point. In an example implementation, signal processing circuit 210 processes the second measurement electrically using the low-resolution locating information to enable the processing of the second measurement to determine the high-resolution locating information. In accordance with this implementation, the high-resolution locating information includes a relatively high resolution estimate of the distance between the reference location 132 and the current point 134.

In some example embodiments, one or more steps 702, 704, 706, and/or 708 of flowchart 700 may not be performed. Moreover, steps in addition to or in lieu of steps 702, 704, 706, and/or 708 may be performed. For instance, in an example embodiment, the method of flowchart 700 further includes one or more of the steps shown in flowchart 800 of FIG. 8. As shown in FIG. 8, the method of flowchart 800 begins at step 802. In step 802, coherent light is modulated in frequency to provide the modulated coherent light. In an example implementation, laser source 202 modulates the coherent light 244 in frequency to provide the modulated coherent light.

At step 804, the modulated coherent light is split into a reference beam and a detection beam. In an example implementation, splitting optics 204 split the modulated coherent light into the reference beam 246 and the detection beam 126.

At step 806, a frequency range over which a beat frequency of a beat signal is to be searched is reduced by more than a factor of two to enable the processing of the second measurement to determine the high-resolution locating information. The beat signal is an electrical result of optical mixing of the reference beam and a reflected detection beam at a surface of a light detecting structure. The reflected detection beam results from reflection of the detection beam from the current point. In an example implementation, depth

measurement subsystem 102 reduces the frequency range over which the beat frequency of the beat signal is to be searched by more than a factor of two to enable the processing of the second measurement to determine the high-resolution locating information.

In another example embodiment, the method of flowchart 700 further includes one or more of the steps shown in flowchart 900 of FIG. 9. As shown in FIG. 9, the method of flowchart 900 begins at step 902. In step 902, coherent light is modulated in amplitude over time to provide the modulated coherent light. In an example implementation, laser source 202 modulates the coherent light 244 in amplitude over time to provide the modulated coherent light.

At step 904, a reference signal and a detection beam are formed. The detection beam is formed from the modulated coherent light. In an example implementation, depth measurement subsystem 102 forms the reference signal 248A and the detection beam 126. In accordance with this implementation, the detection beam 126 is formed from the modulated coherent light.

At step 906, a phase difference between the reference signal and a reflected detection beam is measured. The reflected detection beam results from reflection of the detection beam from the current point. In an example implementation, depth measurement subsystem 102 measures a phase difference between the reference signal 248A and the reflected detection beam 128.

At step 908, the high-resolution locating information is determined based on the phase difference and the low-resolution locating information. In an example implementation, depth measurement subsystem 102 determines the high-resolution locating information based on the phase difference and the low-resolution locating information.

As shown in FIG. 10, the method of flowchart 1000 begins at step 1002. In step 1002, a depth map is formed. In an example implementation, controller 108 forms the depth map 138. For instance, controller 108 may form the depth map 138 based on a scan of a beam of laser light from the reference location 132 over points (e.g., a grid of points) in the field of view 130.

At step 1004, locations of objects in the depth map are interpreted. In an example implementation, controller 108 interprets the locations of the objects in the depth map 138. For instance, measured distances from the reference location 132 to respective points in the field of view 130 may indicate the locations of the objects in the depth map 138. Accordingly, controller 108 may use the measured distances to interpret the locations of the objects in the depth map 138.

At step 1006, surfaces of the objects in the depth map are identified. For example, the surfaces of the objects may be interpreted based at least in part on the locations of the objects. In accordance with this example, interpolation between points that correspond to the locations of the objects may be performed to identify the surfaces of the objects in the depth map. In an example implementation, controller 108 identifies the surfaces of the objects in the depth map 138.

At step 1008, an image is modified in response to the locations of the objects and the surfaces of the objects to provide a modified image. In an example implementation, controller 108 and/or laser projection subsystem 106 modifies the image in response to the locations of the objects and the surfaces of the objects to provide the modified image.

At step 1010, the modified image is projected onto one or more of the surfaces. In an example implementation, laser projection subsystem 106 projects the modified image onto the one or more surfaces. For instance, laser projection

subsystem **106** may use a light redirecting element in MEMS-based scanning subsystem **104** to project the modified image onto the one or more surfaces.

In some example embodiments, one or more steps **1002**, **1004**, **1006**, **1008**, and/or **1010** of flowchart **1000** may not be performed. Moreover, steps in addition to or in lieu of steps **1002**, **1004**, **1006**, **1008**, and/or **1010** may be performed.

III. Example Computing System Implementation

Example embodiments, systems, components, subcomponents, devices, methods, flowcharts, steps, and/or the like described herein, including but not limited to flowchart **500**, flowchart **600**, flowchart **700**, flowchart **800**, flowchart **900**, and flowchart **1000** may be implemented in hardware (e.g., hardware logic/electrical circuitry), or any combination of hardware with software (computer program code configured to be executed in one or more processors or processing devices) and/or firmware. The embodiments described herein, including systems, methods/processes, and/or apparatuses, may be implemented using well known computing devices, such as computer **1100** shown in FIG. **11**. For example, each of the steps of flowchart **500**, each of the steps of flowchart **600**, each of the steps of flowchart **700**, each of the steps of flowchart **800**, each of the steps of flowchart **900**, and each of the steps of flowchart **1000** may be implemented using one or more computers **1100**.

Computer **1100** can be any commercially available and well known communication device, processing device, and/or computer capable of performing the functions described herein, such as devices/computers available from International Business Machines®, Apple®, HP®, Dell®, Cray®, Samsung®, Nokia®, etc. Computer **1100** may be any type of computer, including a server, a desktop computer, a laptop computer, a tablet computer, a wearable computer such as a smart watch or a head-mounted computer, a personal digital assistant, a cellular telephone, etc.

Computer **1100** includes one or more processors (also called central processing units, or CPUs), such as a processor **1106**. Processor **1106** is connected to a communication infrastructure **1102**, such as a communication bus. In some embodiments, processor **1106** can simultaneously operate multiple computing threads. Computer **1100** also includes a primary or main memory **1108**, such as random access memory (RAM). Main memory **1108** has stored therein control logic **1124** (computer software), and data.

Computer **1100** also includes one or more secondary storage devices **1110**. Secondary storage devices **1110** include, for example, a hard disk drive **1112** and/or a removable storage device or drive **1114**, as well as other types of storage devices, such as memory cards and memory sticks. For instance, computer **1100** may include an industry standard interface, such a universal serial bus (USB) interface for interfacing with devices such as a memory stick. Removable storage drive **1114** represents a floppy disk drive, a magnetic tape drive, a compact disk drive, an optical storage device, tape backup, etc.

Removable storage drive **1114** interacts with a removable storage unit **1116**. Removable storage unit **1116** includes a computer useable or readable storage medium **1118** having stored therein computer software **1126** (control logic) and/or data. Removable storage unit **1116** represents a floppy disk, magnetic tape, compact disk (CD), digital versatile disc (DVD), Blu-ray disc, optical storage disk, memory stick, memory card, or any other computer data storage device. Removable storage drive **1114** reads from and/or writes to removable storage unit **1116** in a well-known manner.

Computer **1100** also includes input/output/display devices **1104**, such as touchscreens, LED and LCD displays, keyboards, pointing devices, etc.

Computer **1100** further includes a communication or network interface **1120**. Communication interface **1120** enables computer **1100** to communicate with remote devices. For example, communication interface **1120** allows computer **1100** to communicate over communication networks or mediums **1122** (representing a form of a computer useable or readable medium), such as local area networks (LANs), wide area networks (WANs), the Internet, etc. Network interface **1120** may interface with remote sites or networks via wired or wireless connections. Examples of communication interface **1120** include but are not limited to a modem (e.g., for 3G and/or 4G communication(s)), a network interface card (e.g., an Ethernet card for Wi-Fi and/or other protocols), a communication port, a Personal Computer Memory Card International Association (PCMCIA) card, a wired or wireless USB port, etc. Control logic **1128** may be transmitted to and from computer **1100** via the communication medium **1122**.

Any apparatus or manufacture comprising a computer useable or readable medium having control logic (software) stored therein is referred to herein as a computer program product or program storage device. Examples of a computer program product include but are not limited to main memory **1108**, secondary storage devices **1110** (e.g., hard disk drive **1112**), and removable storage unit **1116**. Such computer program products, having control logic stored therein that, when executed by one or more data processing devices, cause such data processing devices to operate as described herein, represent embodiments. For example, such computer program products, when executed by processor **1106**, may cause processor **1106** to perform any of the steps of flowchart **500** of FIG. **5**, flowchart **600** of FIG. **6**, flowchart **700** of FIG. **7**, flowchart **800** of FIG. **8**, flowchart **900** of FIG. **9**, and/or flowchart **1000** of FIG. **10**.

Devices in which embodiments may be implemented may include storage, such as storage drives, memory devices, and further types of computer-readable media. Examples of such computer-readable storage media include a hard disk, a removable magnetic disk, a removable optical disk, flash memory cards, digital video disks, random access memories (RAMs), read only memories (ROM), and the like. As used herein, the terms “computer program medium” and “computer-readable medium” are used to generally refer to media (e.g., non-transitory media) such as the hard disk associated with a hard disk drive, a removable magnetic disk, a removable optical disk (e.g., CD ROMs, DVD ROMs, etc.), zip disks, tapes, magnetic storage devices, optical storage devices, MEMS-based storage devices, nanotechnology-based storage devices, as well as other media such as flash memory cards, digital video discs, RAM devices, ROM devices, and the like. Such computer-readable storage media may store program modules that include computer program logic to implement, for example, embodiments, systems, components, subcomponents, devices, methods, flowcharts, steps, and/or the like described herein (as noted above), and/or further embodiments described herein. Embodiments are directed to computer program products comprising such logic (e.g., in the form of program code, instructions, or software) stored on any computer useable medium. Such program code, when executed in one or more processors, causes a device to operate as described herein.

Note that such computer-readable storage media are distinguished from and non-overlapping with communication media (do not include communication media). Communi-

cation media embodies computer-readable instructions, data structures, program modules or other data in a modulated data signal such as a carrier wave. The term “modulated data signal” means a signal that has one or more of its characteristics set or changed in such a manner as to encode information in the signal. By way of example, and not limitation, communication media includes wireless media such as acoustic, RF, infrared and other wireless media, as well as wired media. Embodiments are also directed to such communication media.

The disclosed technologies can be put into practice using software, firmware, and/or hardware implementations other than those described herein. Any software, firmware, and hardware implementations suitable for performing the functions described herein can be used.

IV. Conclusion

While various embodiments have been described above, it should be understood that they have been presented by way of example only, and not limitation. It will be apparent to persons skilled in the relevant art that various changes in form and detail can be made therein without departing from the scope of the embodiments. Thus, the scope of the embodiments should not be limited by any of the above-described exemplary embodiments, but should be defined only in accordance with the following claims and their equivalents.

What is claimed is:

1. A portable panoramic laser mapping system comprising:
 - a depth measurement subsystem configured to measure a distance between a reference location and a current point, the depth measurement subsystem including:
 - a laser source configured to generate coherent light, the laser source capable of modulating the coherent light;
 - splitting optics configured to create a reference beam of light and a detection beam of light from the coherent light;
 - a light detecting structure configured to convert the reference beam and a reflected detection beam into electrical signals, the reflected detection beam resulting from reflection of the detection beam from the current point; and
 - a signal processing circuit configured to determine locating information based on the electrical signals, the locating information indicating the distance between the reference location and the current point;
 - a microelectromechanical systems-based scanning subsystem including:
 - one or more mirrors; and
 - a light redirecting element having a microelectromechanical structure that is configured to perform a scan of the current point over a field of view using the one or more mirrors;
 - a controller configured to coordinate the locating information with the scan of the current point over the field of view to form a depth map; and
 - a laser projection subsystem configured to project an image onto one or more objects, the controller utilizing the depth map to modify the image to provide a modified image, the laser projection subsystem including:
 - one or more visible lasers configured to generate visible light for projecting the modified image onto the one or more objects.

2. The portable panoramic laser mapping system of claim 1, wherein the laser projection subsystem uses the light redirecting element of the microelectromechanical systems-based scanning subsystem to project the modified image onto the one or more objects.

3. The portable panoramic laser mapping system of claim 1, wherein the microelectromechanical systems-based scanning subsystem further includes a second light redirecting element, which is different from the light redirecting element configured to perform the scan of the current point over the field of view; and

wherein the laser projection subsystem uses the second light redirecting element of the microelectromechanical systems-based scanning subsystem to project the modified image onto the one or more objects.

4. The portable panoramic laser mapping system of claim 1, wherein the light redirecting element further comprises: a plurality of flexures that are configured to mount the one or more mirrors.

5. The portable panoramic laser mapping system of claim 4, wherein the flexures are formed from at least one of one or more materials having a fracture toughness of at least 15 MPa ($m^{1/2}$) and a Young's modulus of at least 10 GPa or one or more materials capable of undergoing a strain of two percent without failure.

6. The portable panoramic laser mapping system of claim 4, wherein the one or more mirrors are formed on a substrate material that is different from a material from which the plurality of flexures is formed.

7. The portable panoramic laser mapping system of claim 4, wherein the microelectromechanical structure is configured to pivot at least one of the one or more mirrors about one or more axes over an optical field of view greater than sixty degrees.

8. The portable panoramic laser mapping system of claim 4, wherein the microelectromechanical structure is configured to pivot at least one of the one or more mirrors about one or more axes at a frequency greater than 400 Hz.

9. The portable panoramic laser mapping system of claim 1, further comprising:

a reference fiber optic loop;

wherein the controller is configured to calibrate the depth measurement subsystem using a measurement of a distance through the reference fiber optic loop, the distance through the reference fiber optic loop being a known distance.

10. The portable panoramic laser mapping system of claim 1, wherein the controller is configured to calibrate the depth measurement subsystem using a measurement of a distance from the reference location to a reference object in the field of view, the distance from the reference location to the reference object in the field of view being a known distance.

11. The portable panoramic laser mapping system of claim 1, wherein the laser source is configured to perform a periodic chirp in which the coherent light is modulated in frequency over a chirp period of time; and

wherein the light detecting structure is configured to produce a beat signal, the beat signal being an electrical result of optical mixing of the reference beam and the reflected detection beam at a surface of the light detecting structure, the beat signal having a beat frequency.

12. The portable panoramic laser mapping system of claim 11, wherein the controller is configured to adjust a

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range of frequencies over which the coherent light is modulated during the periodic chirp to adapt resolution of the locating information.

13. The portable panoramic laser mapping system of claim 11, wherein the current point has a pixel size, the pixel size being a distance over which the current point is scanned during the chirp period; and

wherein the laser source is configured to adjust the chirp period of time to adapt the pixel size to be a specified pixel size.

14. The portable panoramic laser mapping system of claim 1, wherein the laser source is configured to modulate the coherent light in amplitude over time; and

wherein the light detecting structure is configured to measure a phase difference between the reference beam and the reflected detection beam.

15. The portable panoramic laser mapping system of claim 1, wherein the controller is further configured to determine velocity of at least one point in the field of view based on the locating information.

16. The portable panoramic laser mapping system of claim 15, wherein the controller is configured to determine a gesture based on velocities of at least two points in the field of view.

17. A system comprising:

a controller configured to form a depth map, the controller further configured to interpret locations of objects in the depth map,

the controller further configured to identify surfaces of the objects in the depth map,

the controller further configured to cause an image to be modified in response to the locations of the objects and the surfaces of the objects to provide a modified image;

a microelectromechanical systems-based scanning subsystem including:

one or more mirrors; and

a light redirecting element having a microelectromechanical structure that is configured to perform a scan of light over a field of view using the one or more mirrors; and

a laser projection subsystem configured to use the light redirecting element of the microelectromechanical systems-based scanning subsystem to project the modified image onto one or more of the surfaces.

18. The system of claim 17, wherein the light redirecting element is configured to perform a scan of a current point over a field of view, the scan facilitating a determination of locating information, the locating information indicating a distance between a reference location and the current point; and

wherein the controller is configured to form the depth map based at least in part on the locating information.

19. The system of claim 17, wherein the microelectromechanical systems-based scanning subsystem further includes a second light redirecting element, which is different from the light redirecting element that is used to project the modified image onto the one or more of the surfaces;

wherein the second light redirecting element has a second microelectromechanical structure that is configured to perform a scan of a current point over a field of view, the scan facilitating a determination of locating information, the locating information indicating a distance between a reference location and the current point; and wherein the controller is configured to form the depth map based at least in part on the locating information.

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20. The system of claim 17, wherein the light redirecting element further comprises:

a plurality of flexures that are configured to mount the one or more mirrors.

21. The system of claim 20, wherein the flexures are formed from at least one of one or more materials having a fracture toughness of at least 15 MPa ($m^{1/2}$) and a Young's modulus of at least 10 GPa or one or more materials capable of undergoing a strain of two percent without failure.

22. The system of claim 20, wherein the one or more mirrors are formed on a substrate material that is different from a material from which the plurality of flexures is formed.

23. The system of claim 20, wherein the microelectromechanical structure is configured to pivot at least one of the one or more mirrors about one or more axes over an optical field of view greater than sixty degrees.

24. The system of claim 20, wherein the microelectromechanical structure is configured to pivot at least one of the one or more mirrors about one or more axes at a frequency greater than 400 Hz.

25. A method comprising:

forming a depth map by a controller;

interpreting locations of objects in the depth map by the controller;

identifying surfaces of the objects in the depth map by the controller;

causing, by the controller, an image to be modified in response to the locations of the objects and the surfaces of the objects to provide a modified image;

performing a scan of light over a field of view, by a microelectromechanical structure that is included in a light redirecting element of a microelectromechanical systems-based scanning subsystem, using one or more mirrors of the microelectromechanical systems-based scanning subsystem; and

using the light redirecting element of the microelectromechanical systems-based scanning subsystem, by a laser projection subsystem, to project the modified image onto one or more of the surfaces.

26. The method of claim 25, further comprising:

performing a scan of a current point over a field of view by the light redirecting element, the scan of the current point facilitating a determination of locating information, the locating information indicating a distance between a reference location and the current point;

wherein forming the depth map comprises:

forming the depth map based at least in part on the locating information.

27. The method of claim 25, further comprising:

performing a scan of a current point over a field of view by a second microelectromechanical structure of a second light redirecting element that is included in the microelectromechanical systems-based scanning subsystem, the second light redirecting element is different from the light redirecting element that is used to project the modified image onto the one or more of the surfaces, the scan of the current point facilitating a determination of locating information, the locating information indicating a distance between a reference location and the current point;

wherein forming the depth map comprises:

forming the depth map based at least in part on the locating information.